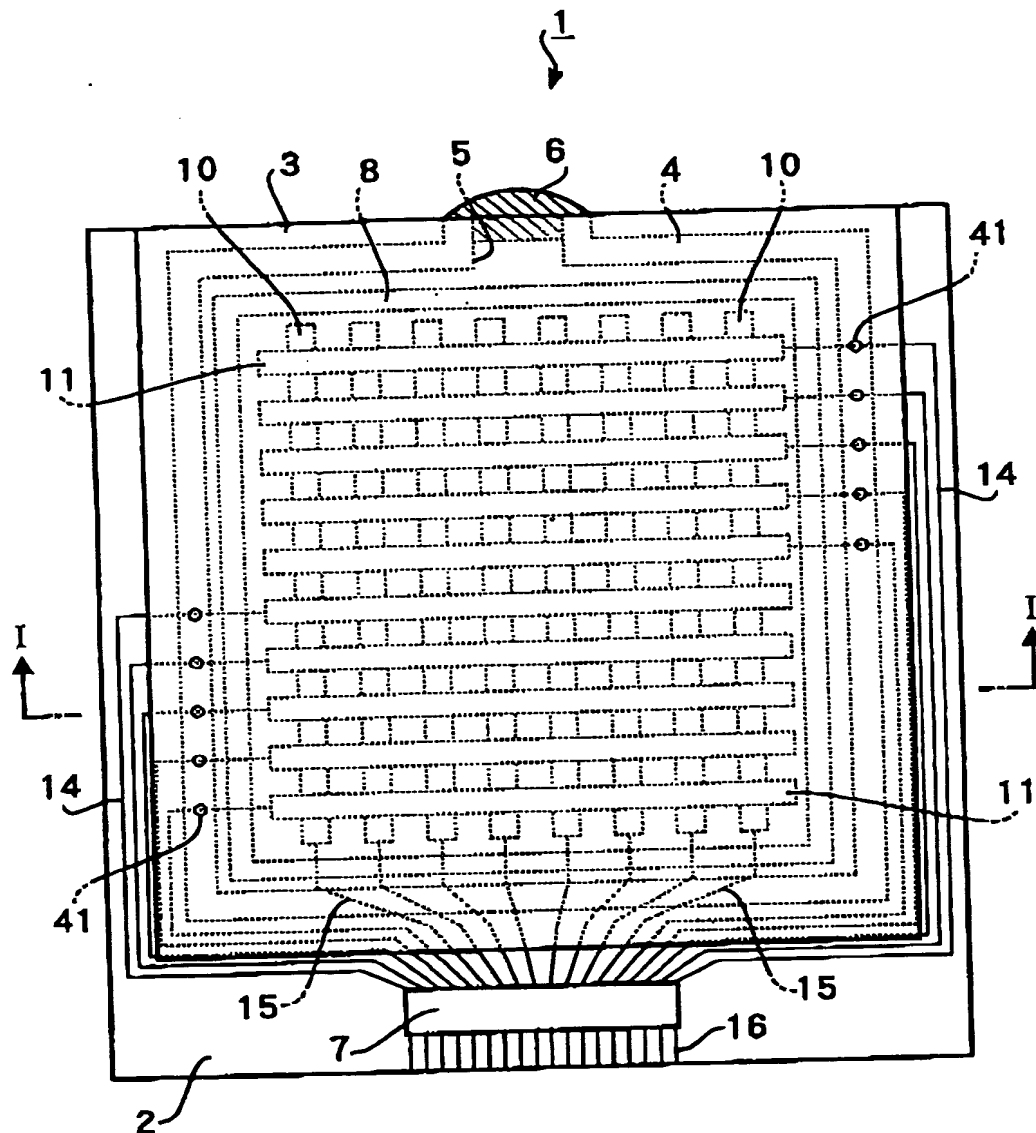


FIG. 1



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FIG. 2

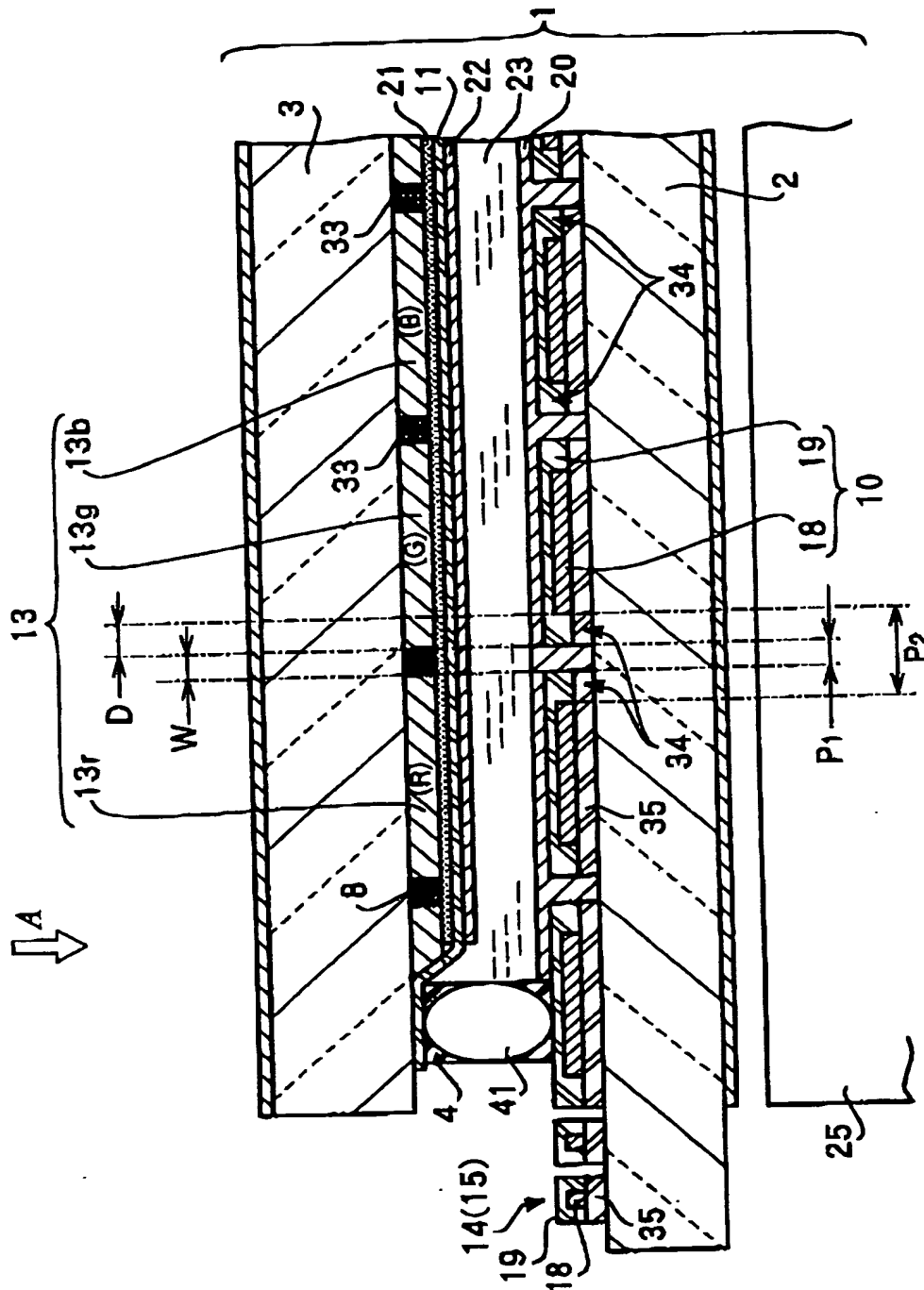


FIG. 3

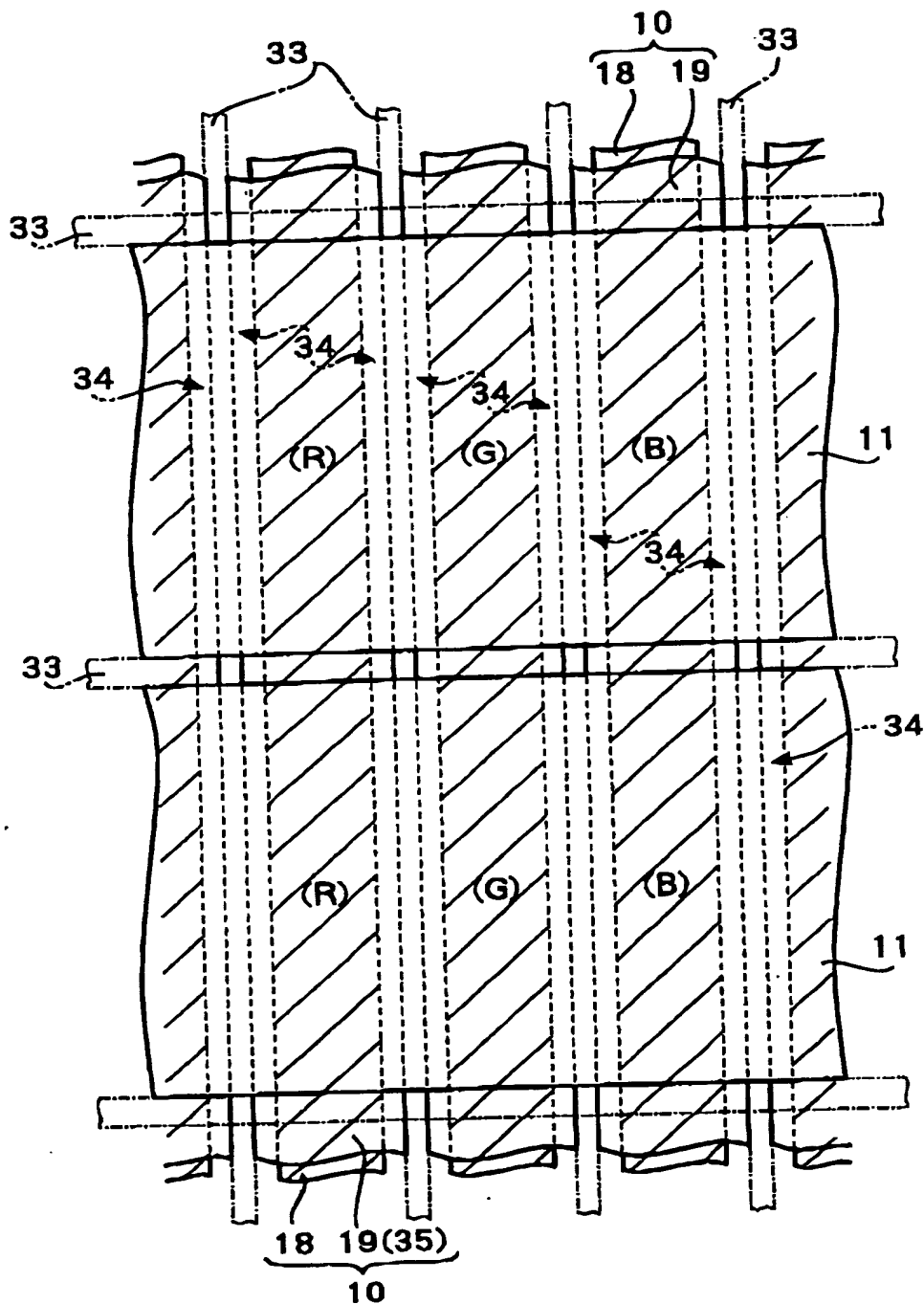
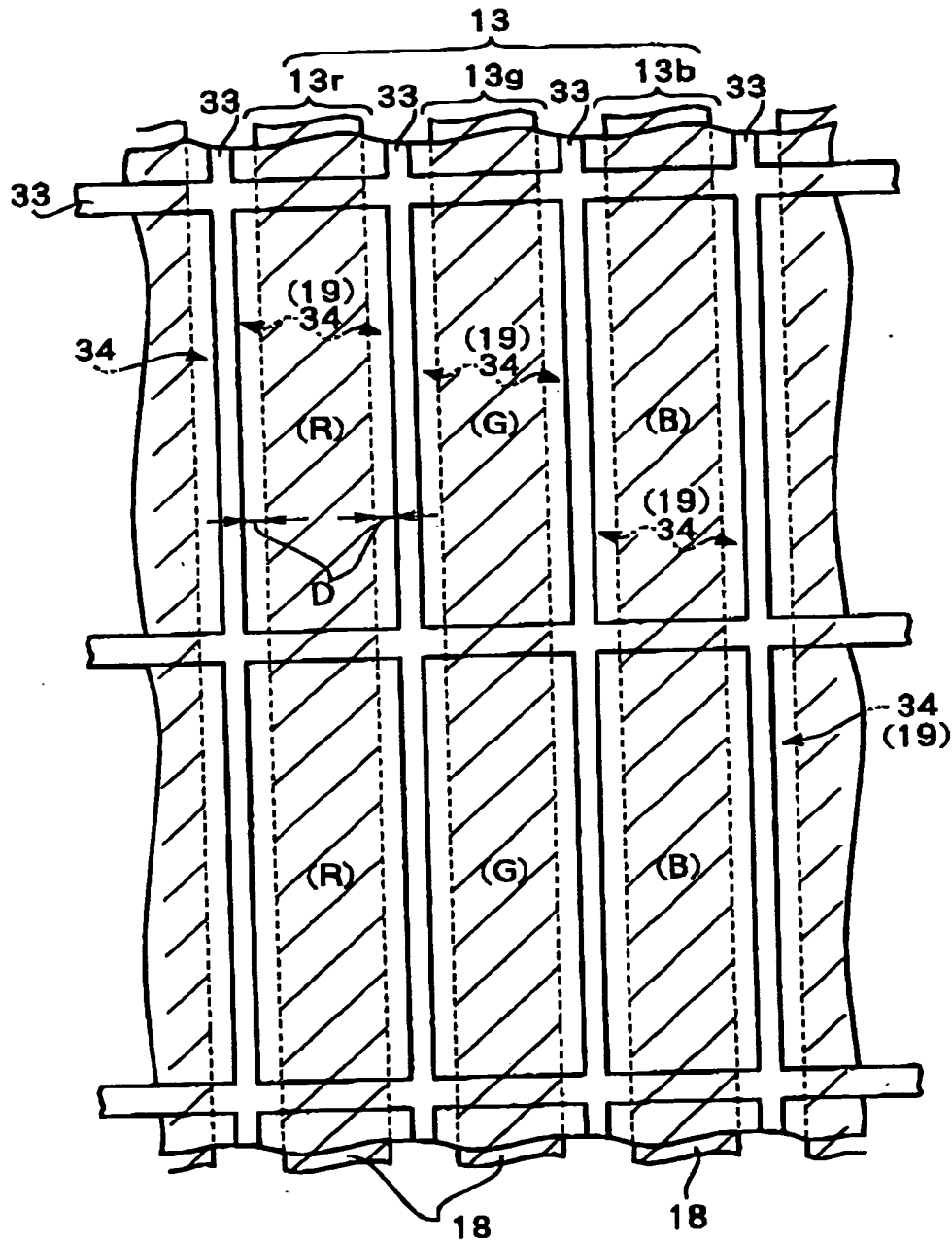


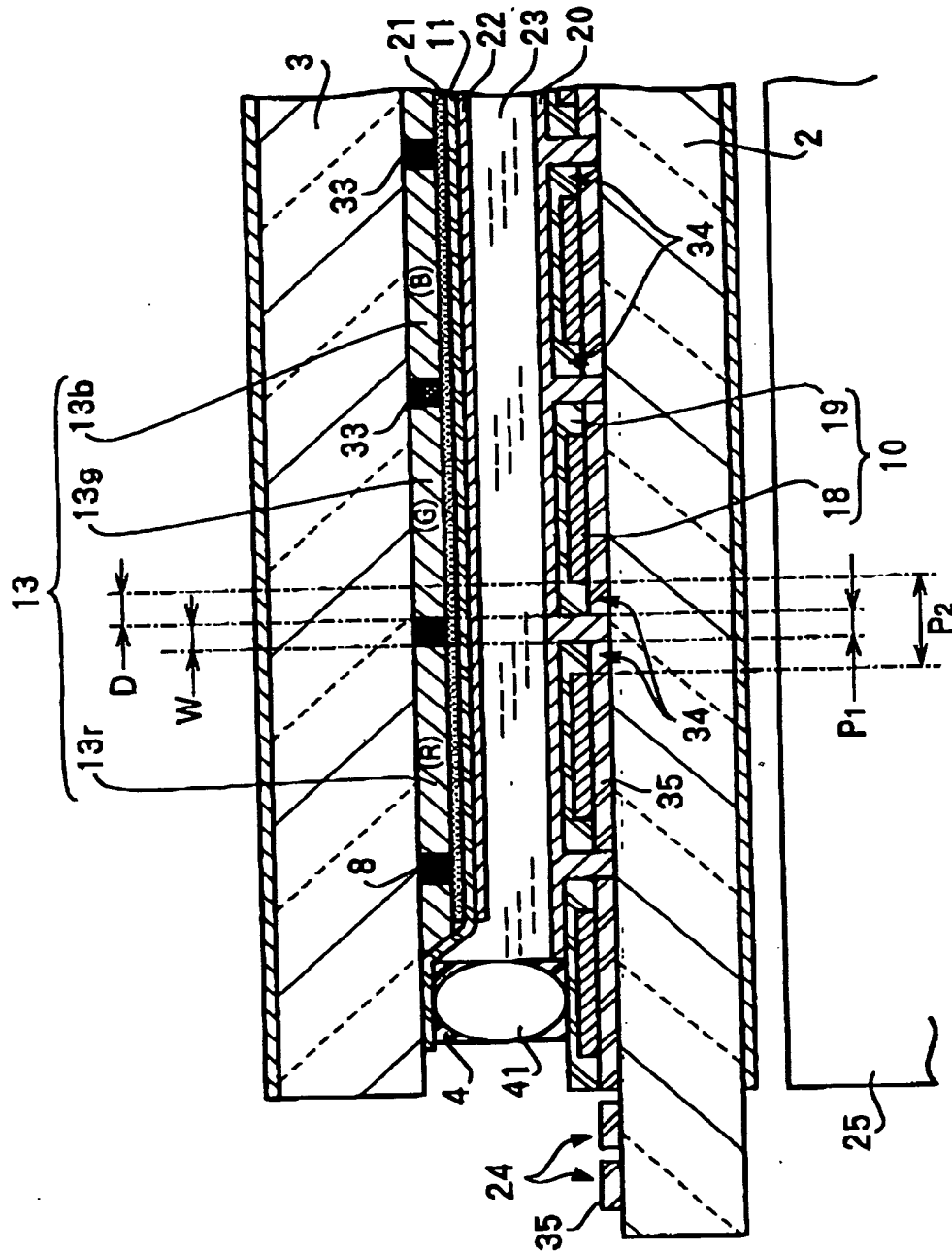
FIG. 4



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FIG. 5



[illegible]

FIG. 7

PRIOR ART

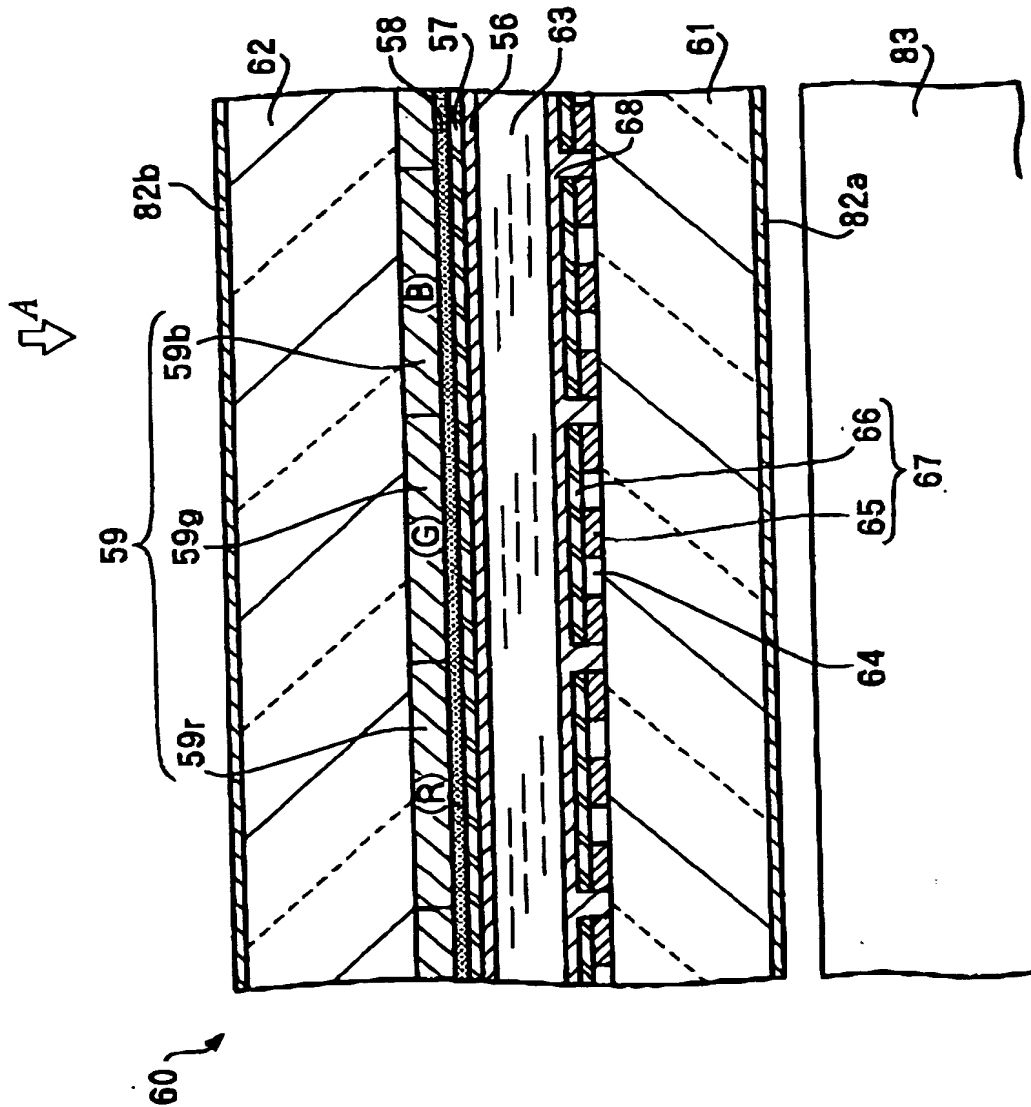
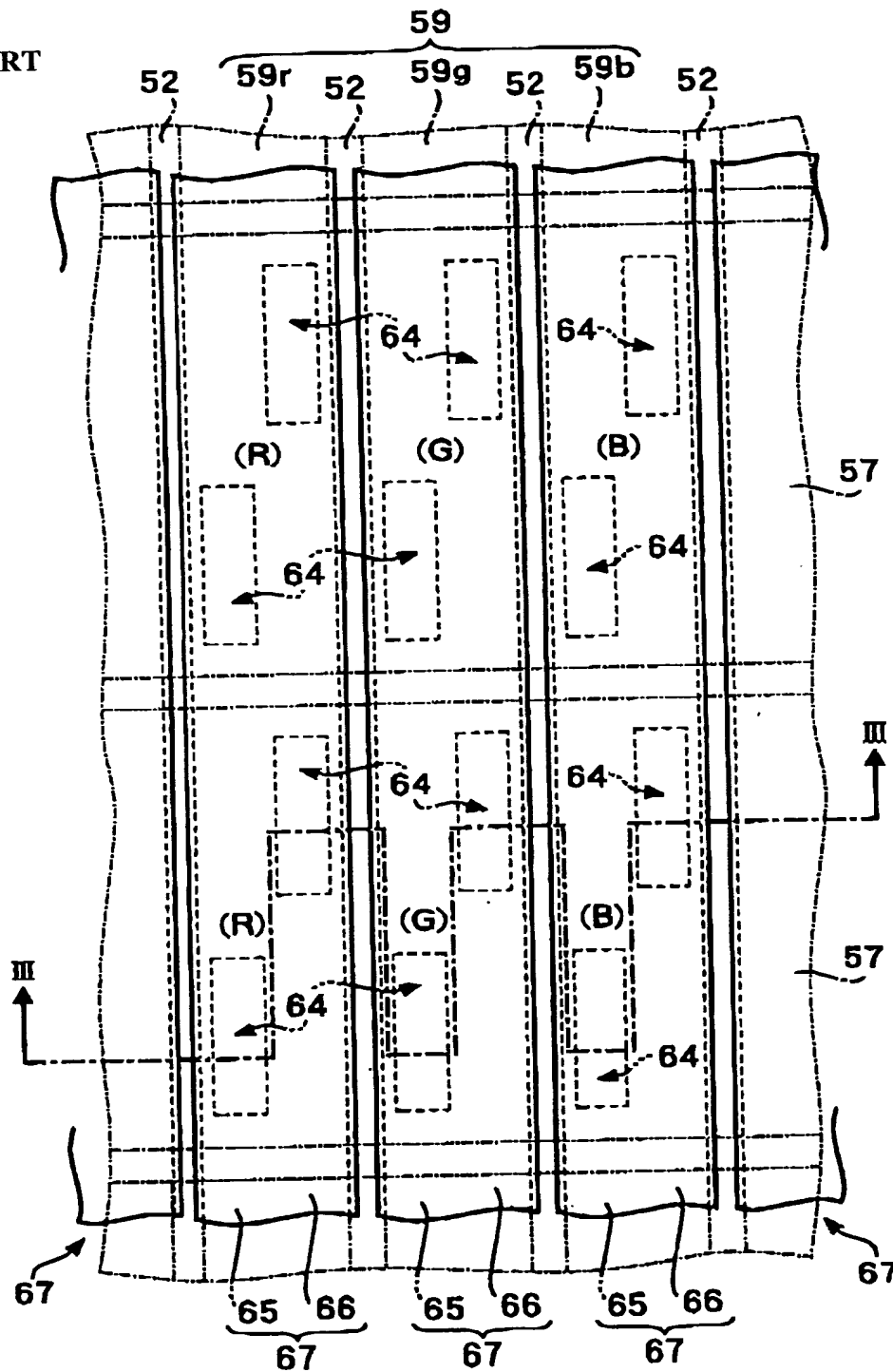


FIG. 8

PRIOR ART



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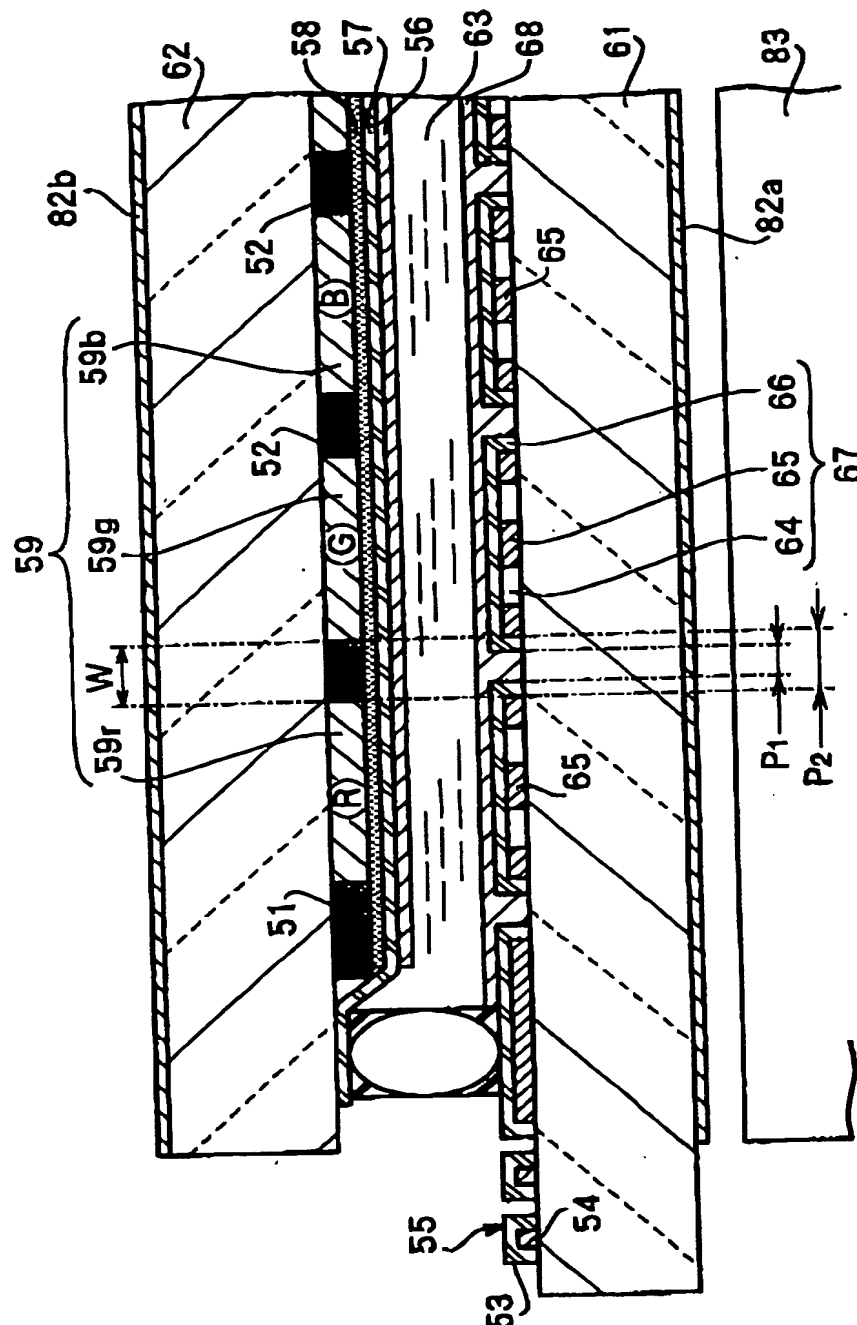
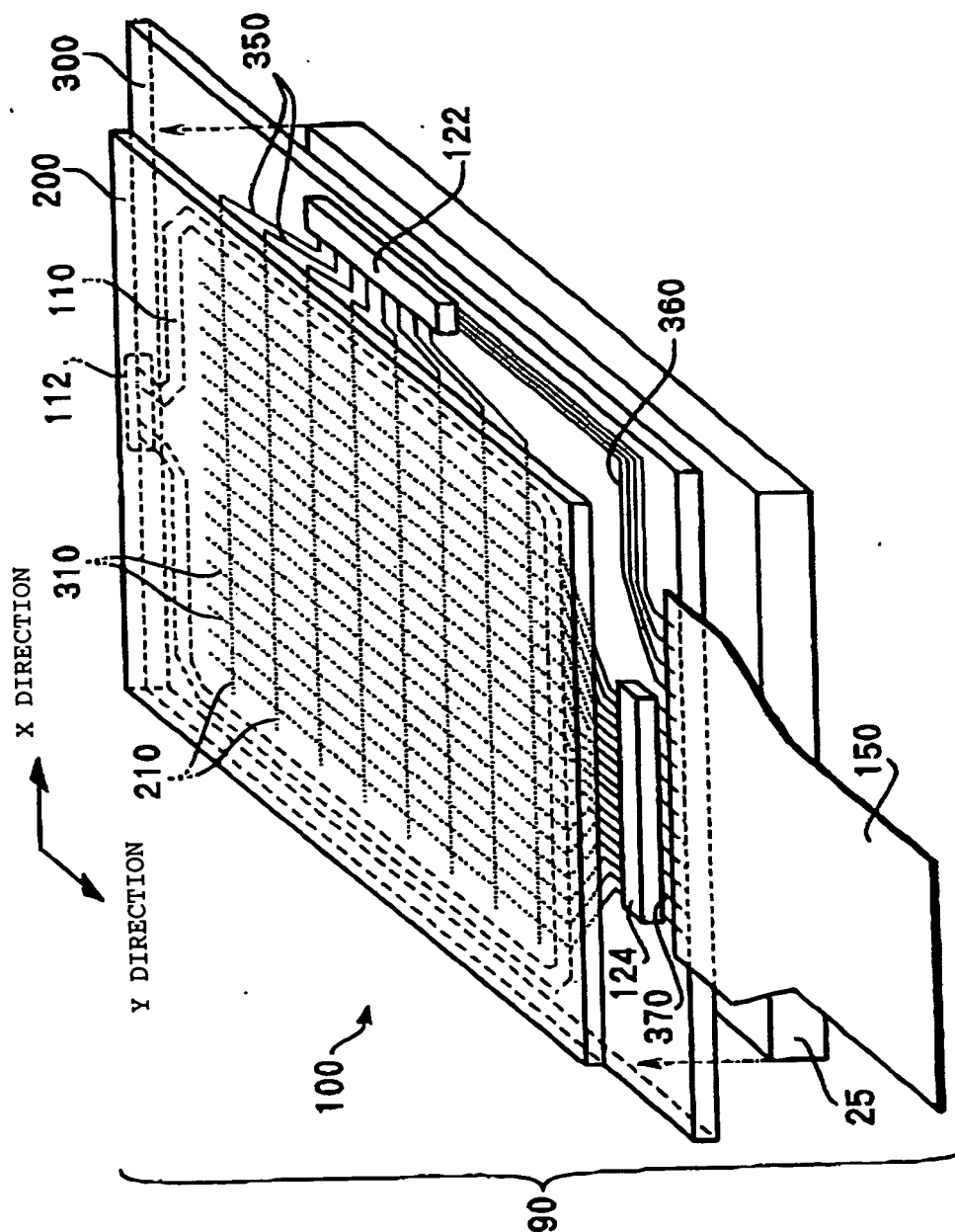


FIG. 10



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FIG. 11

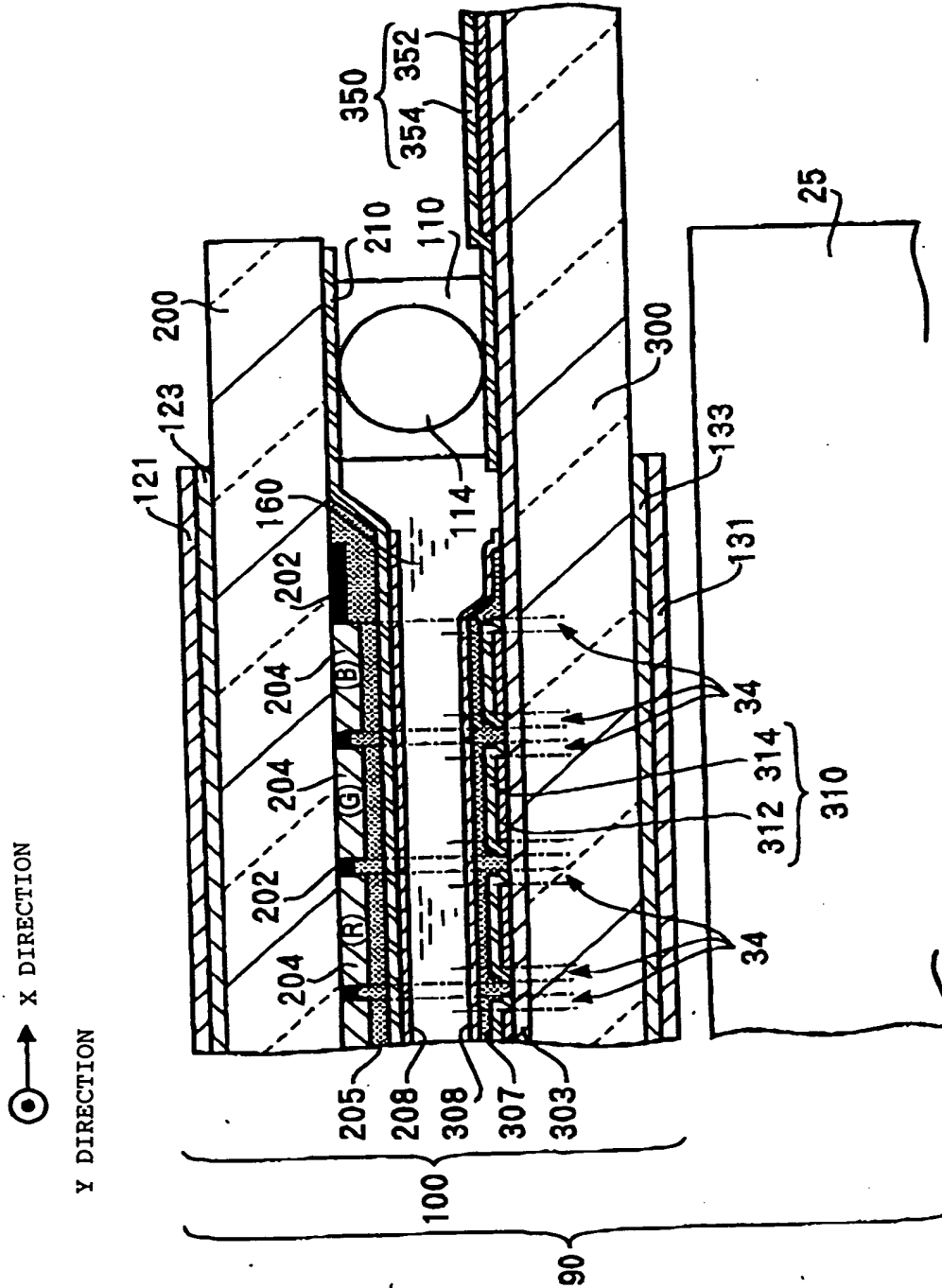
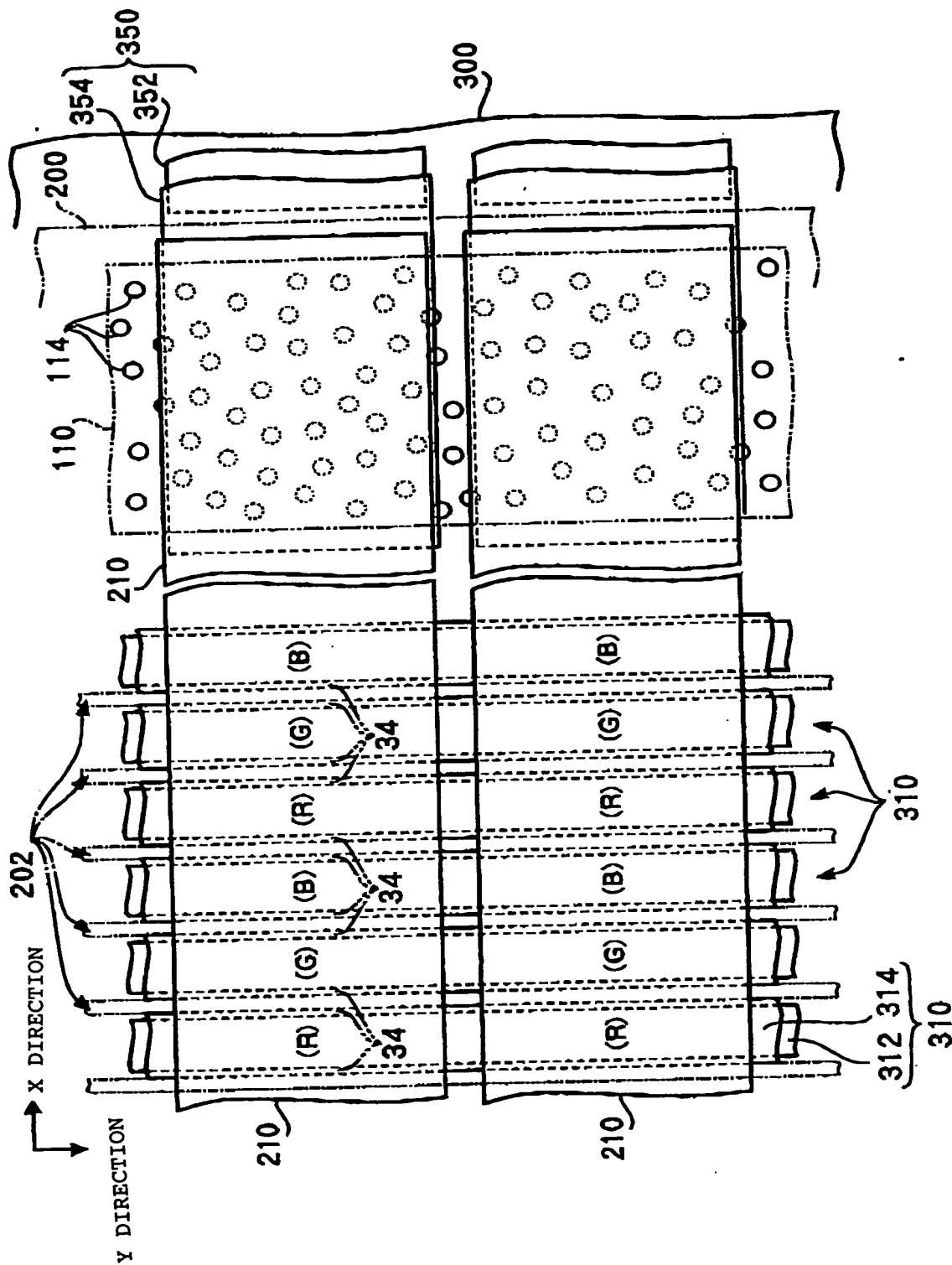


FIG. 12



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FIG. 13

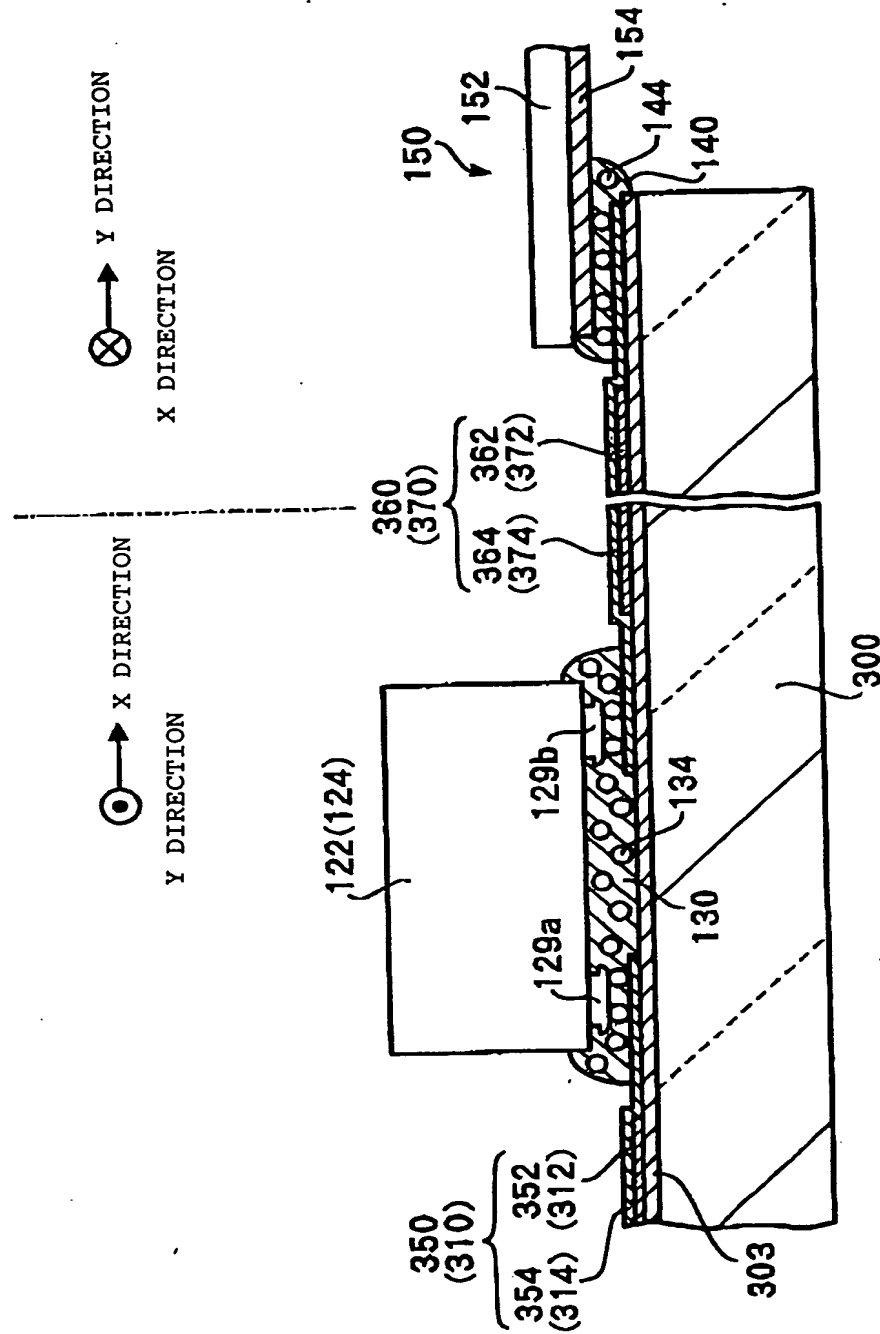
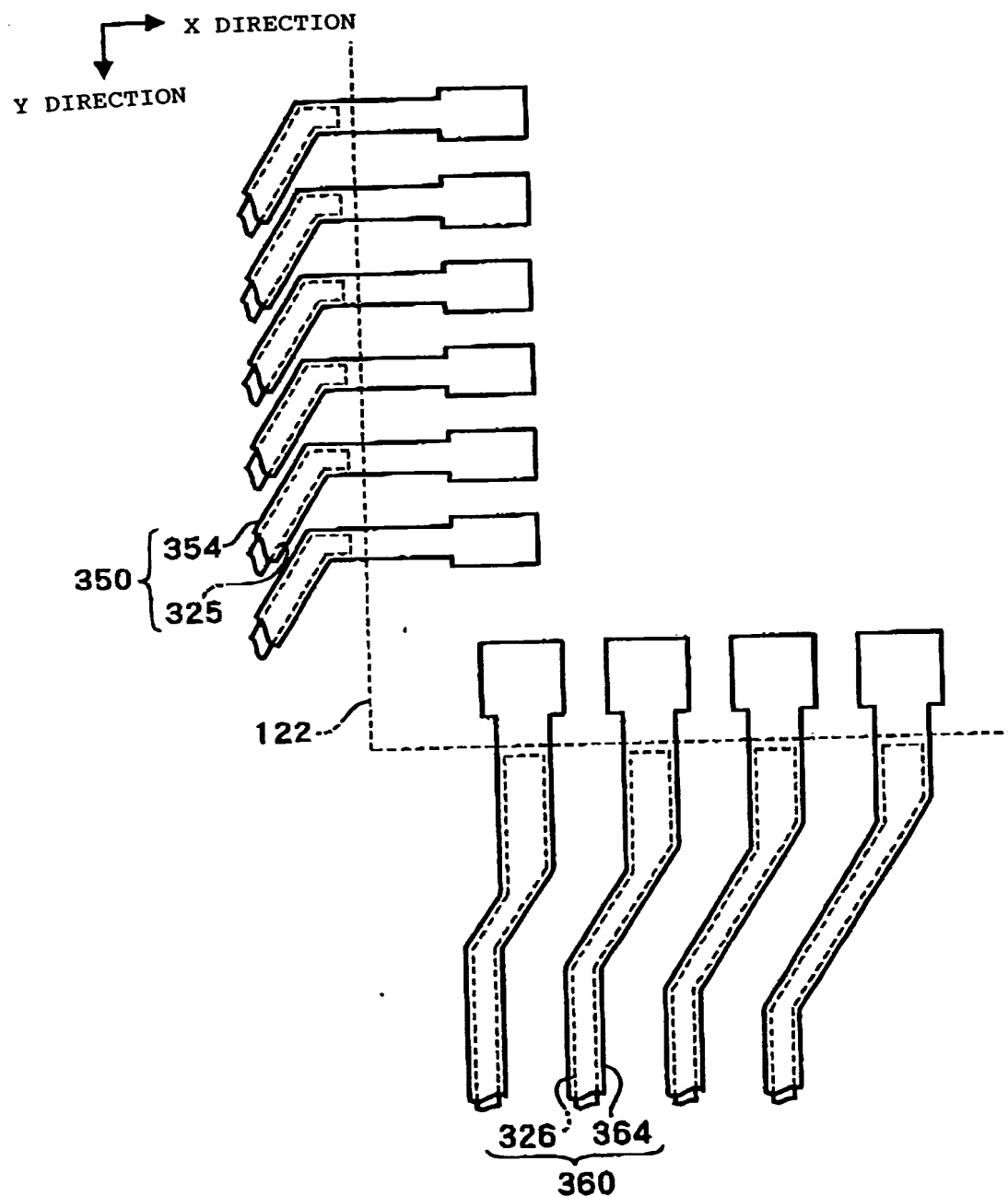


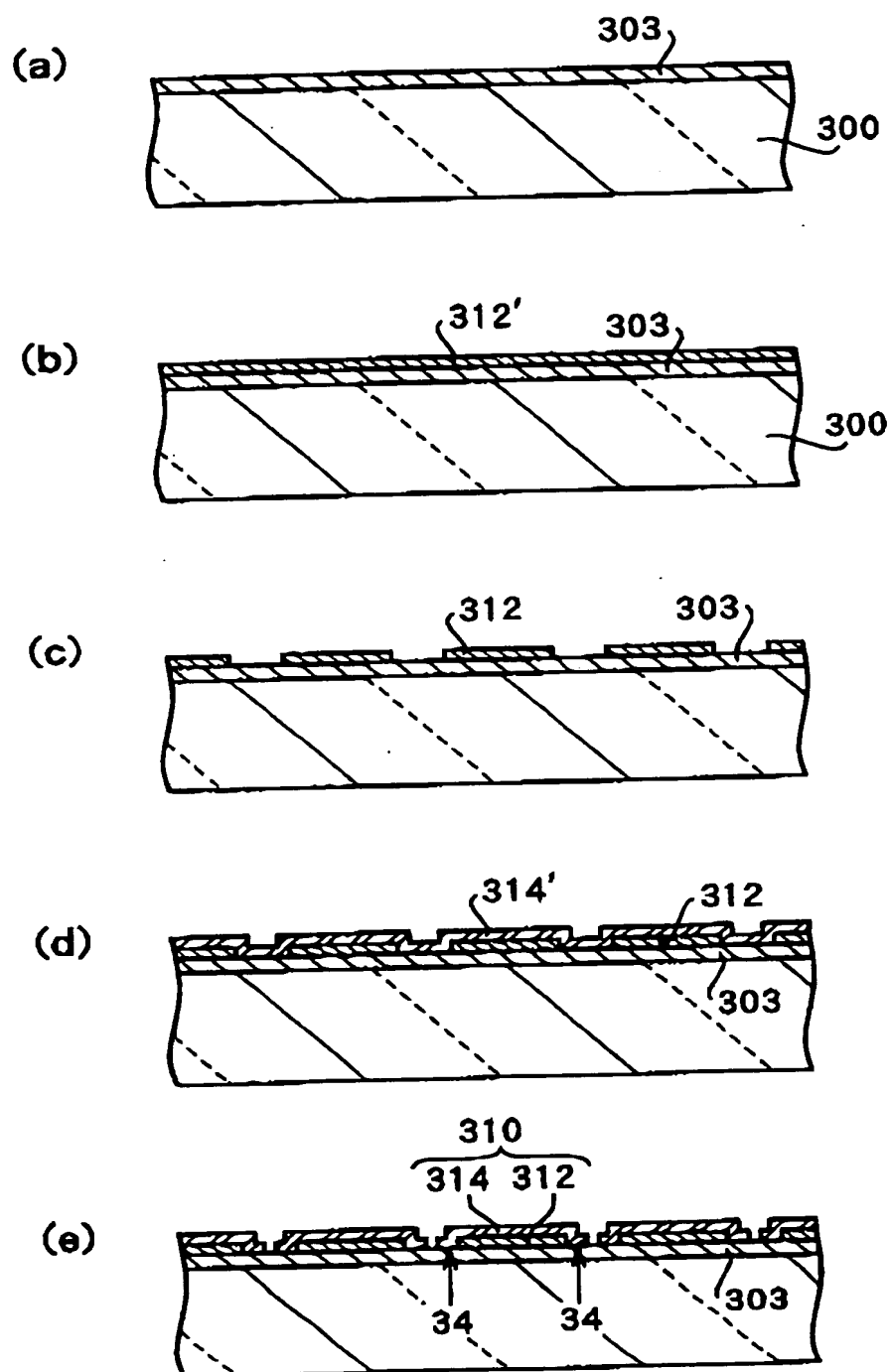
FIG. 14



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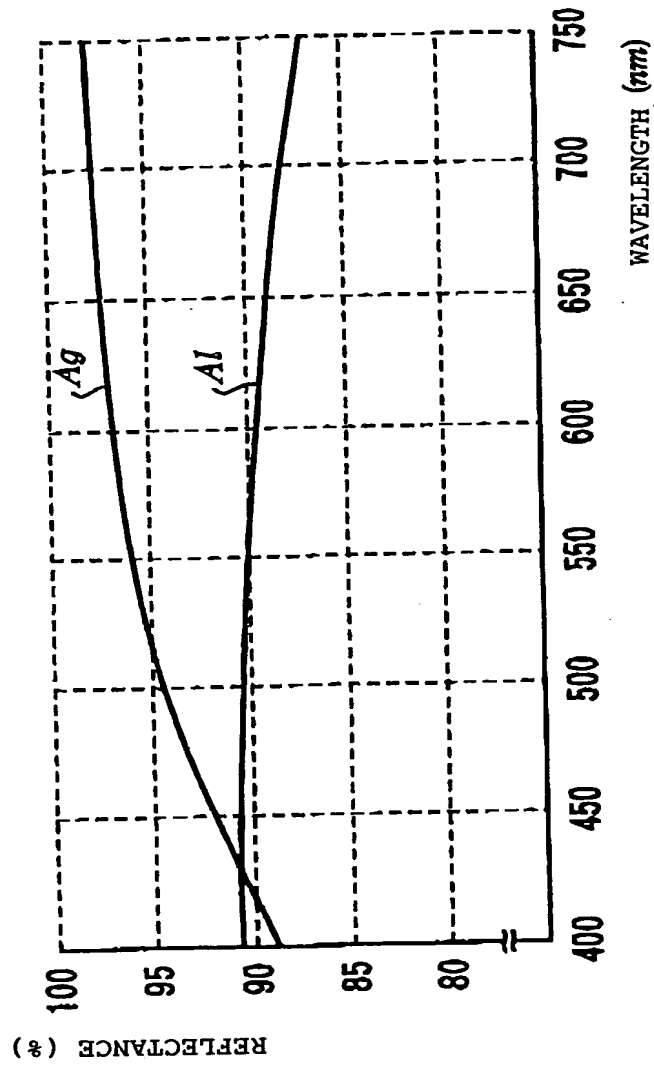
FIG. 15



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FIG. 16



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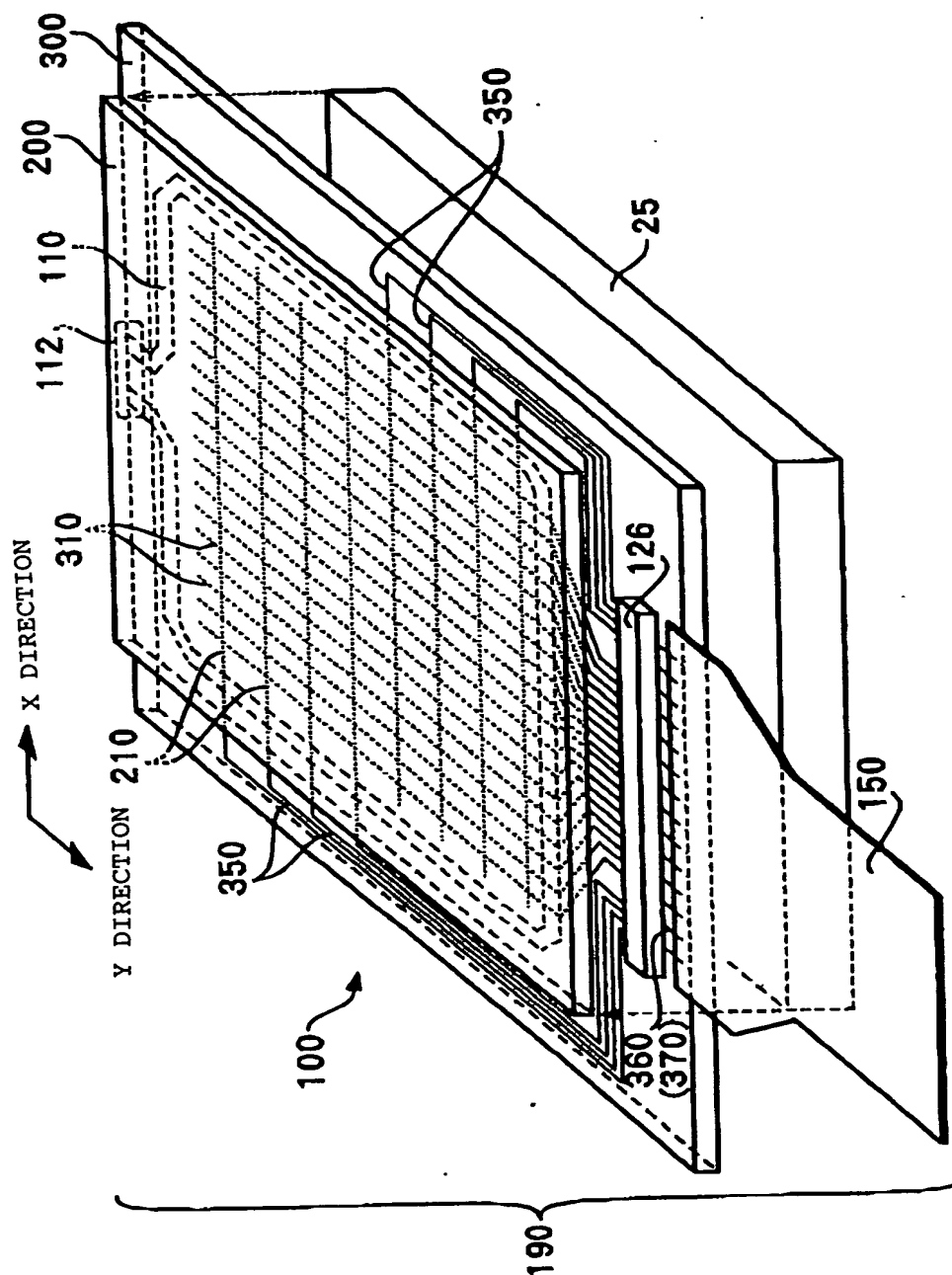
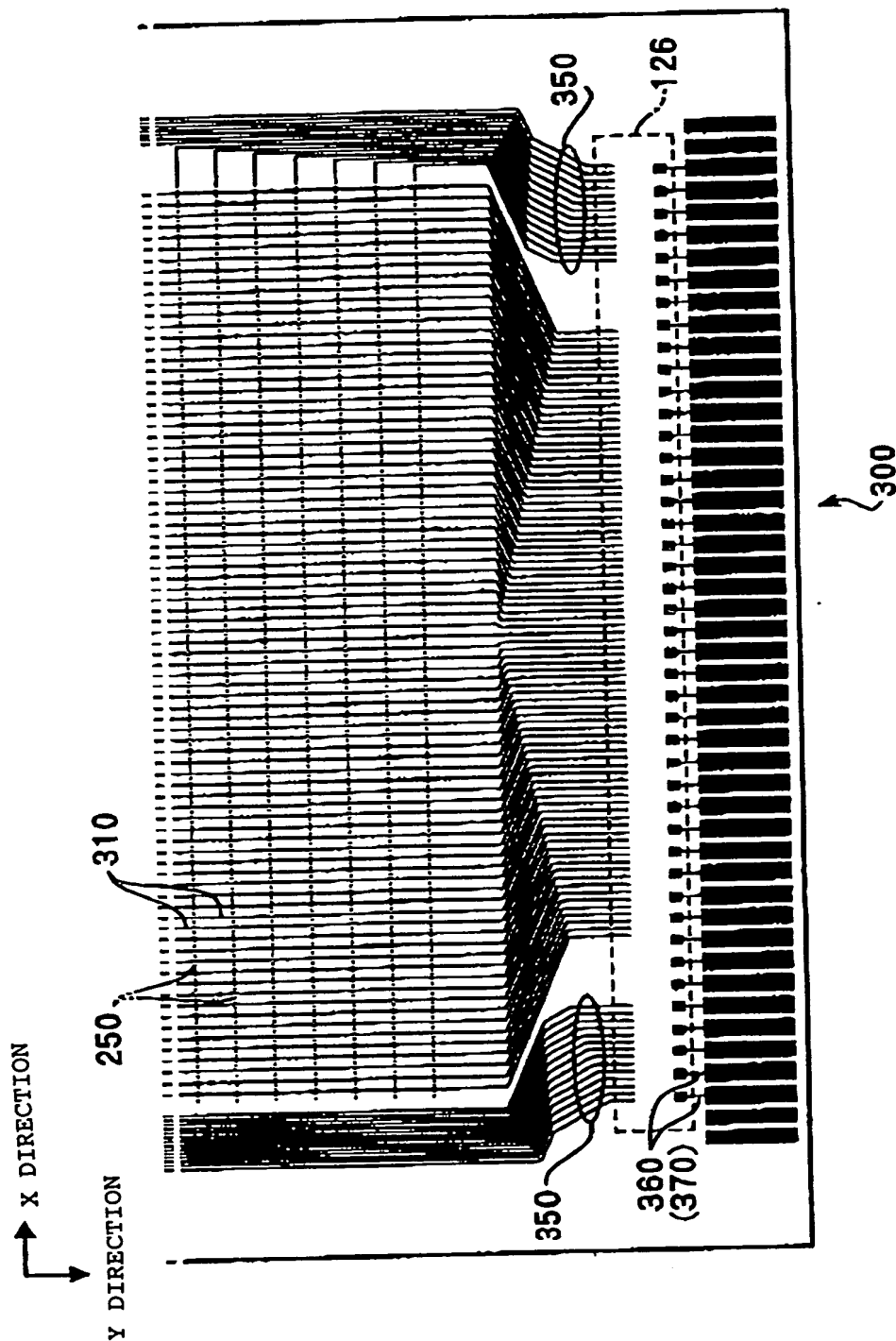


FIG. 18



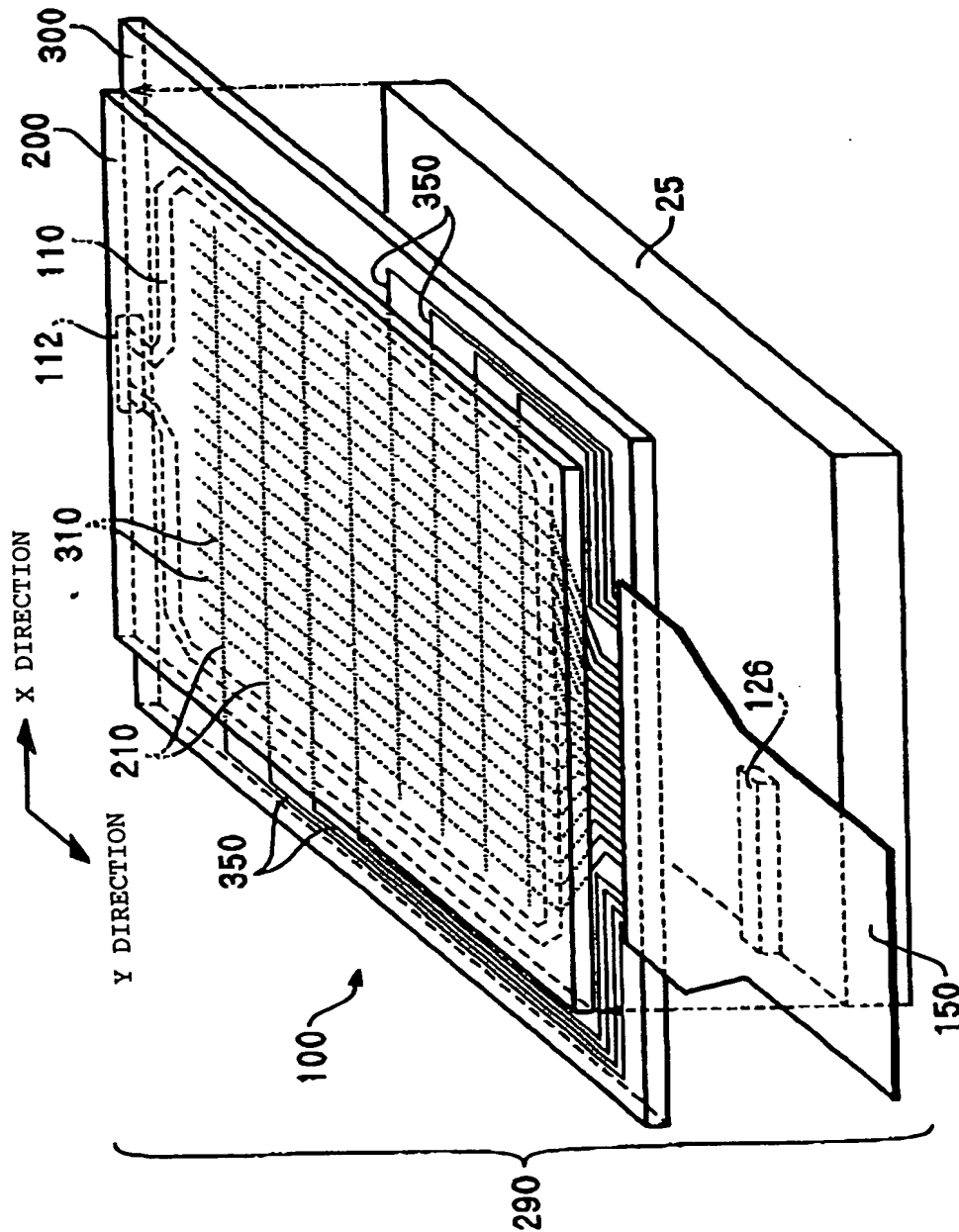
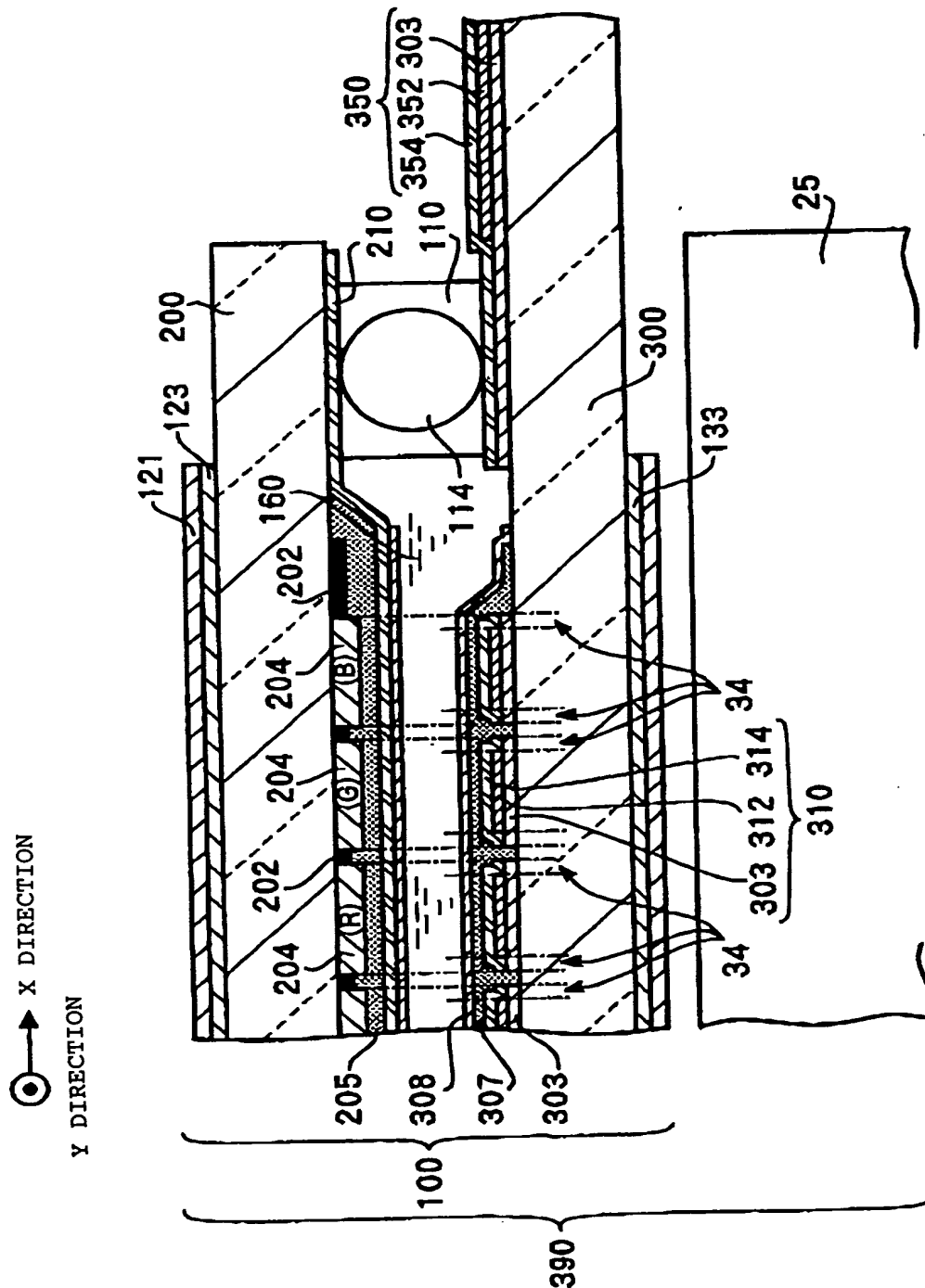


FIG. 20



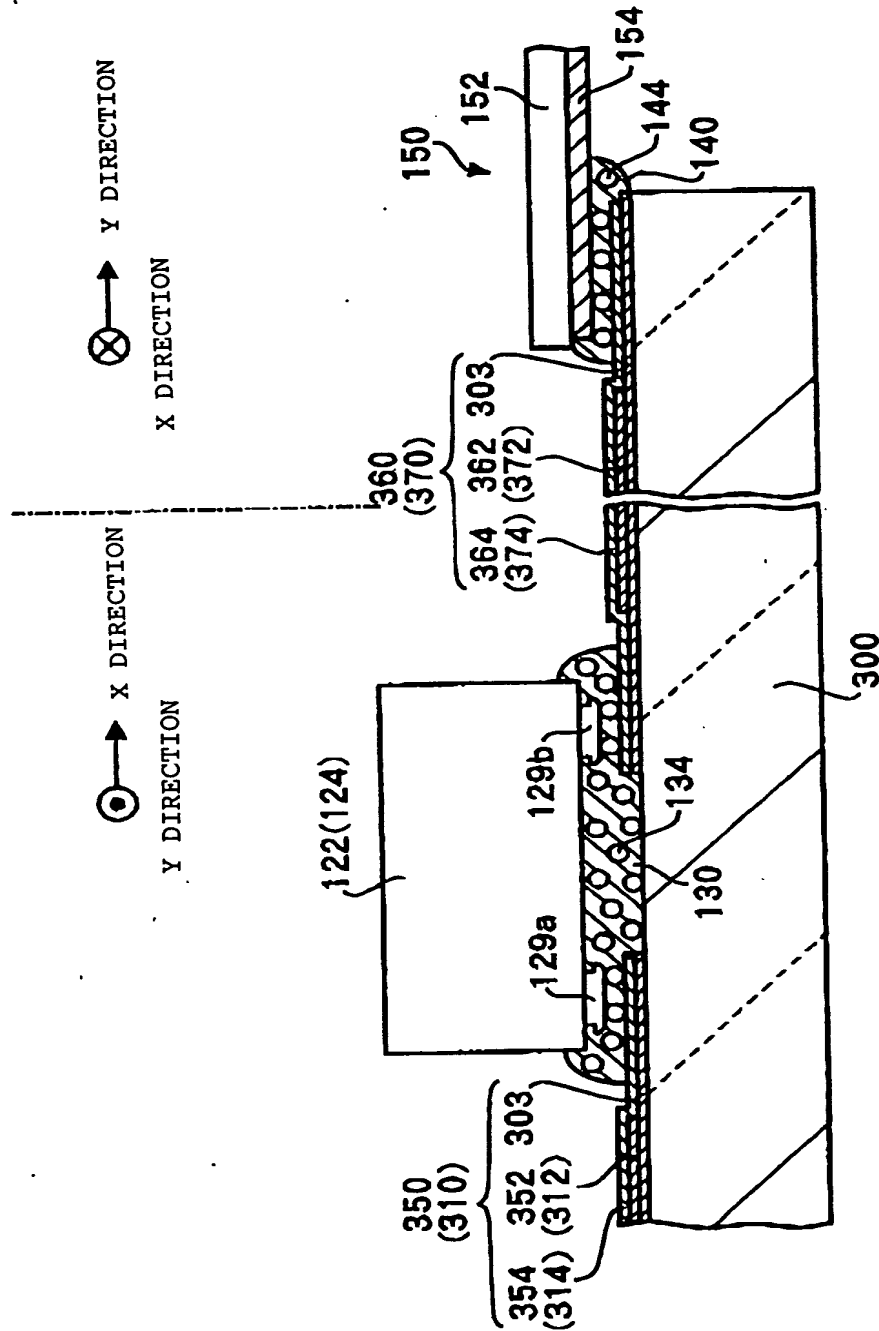
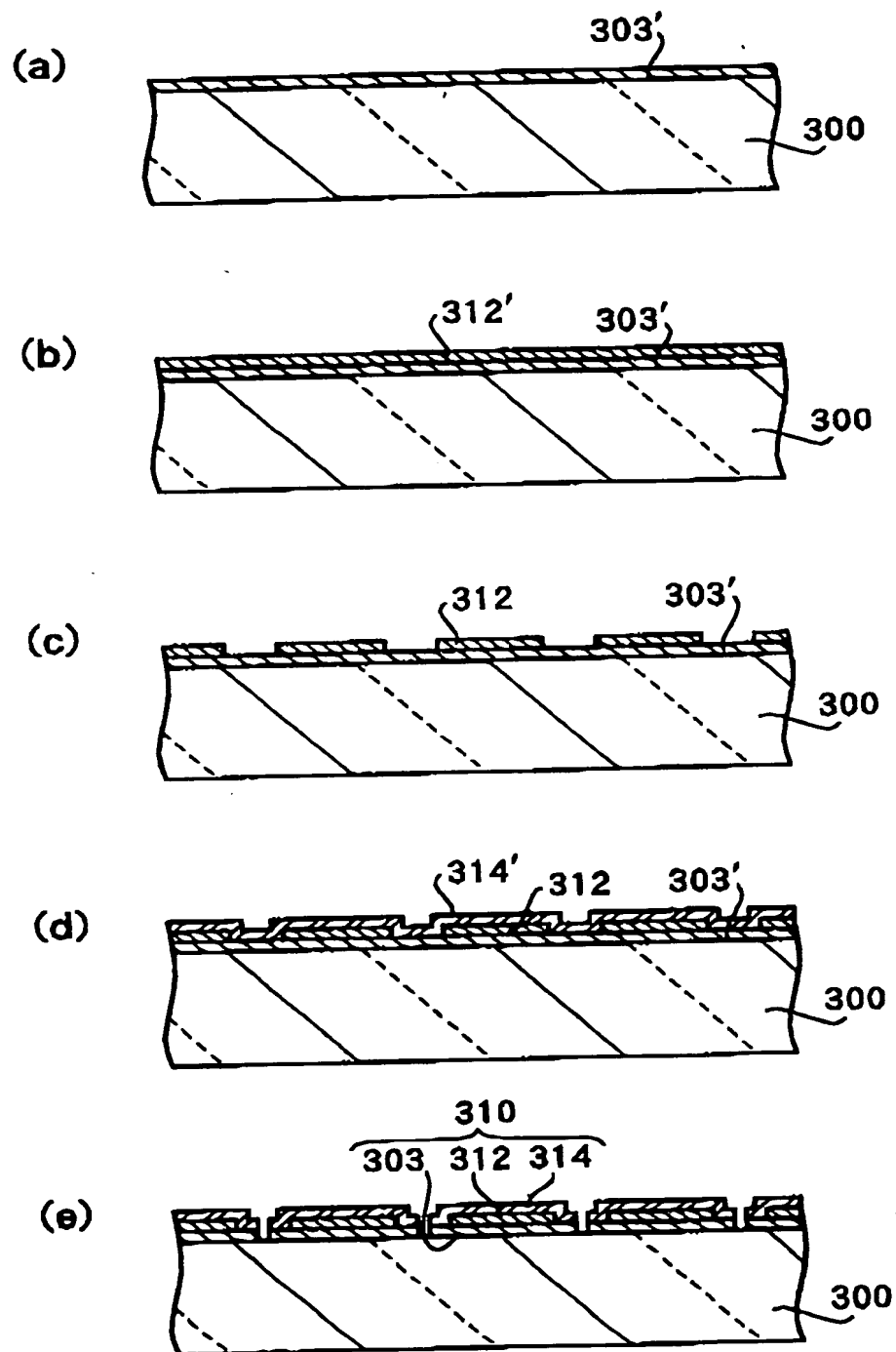
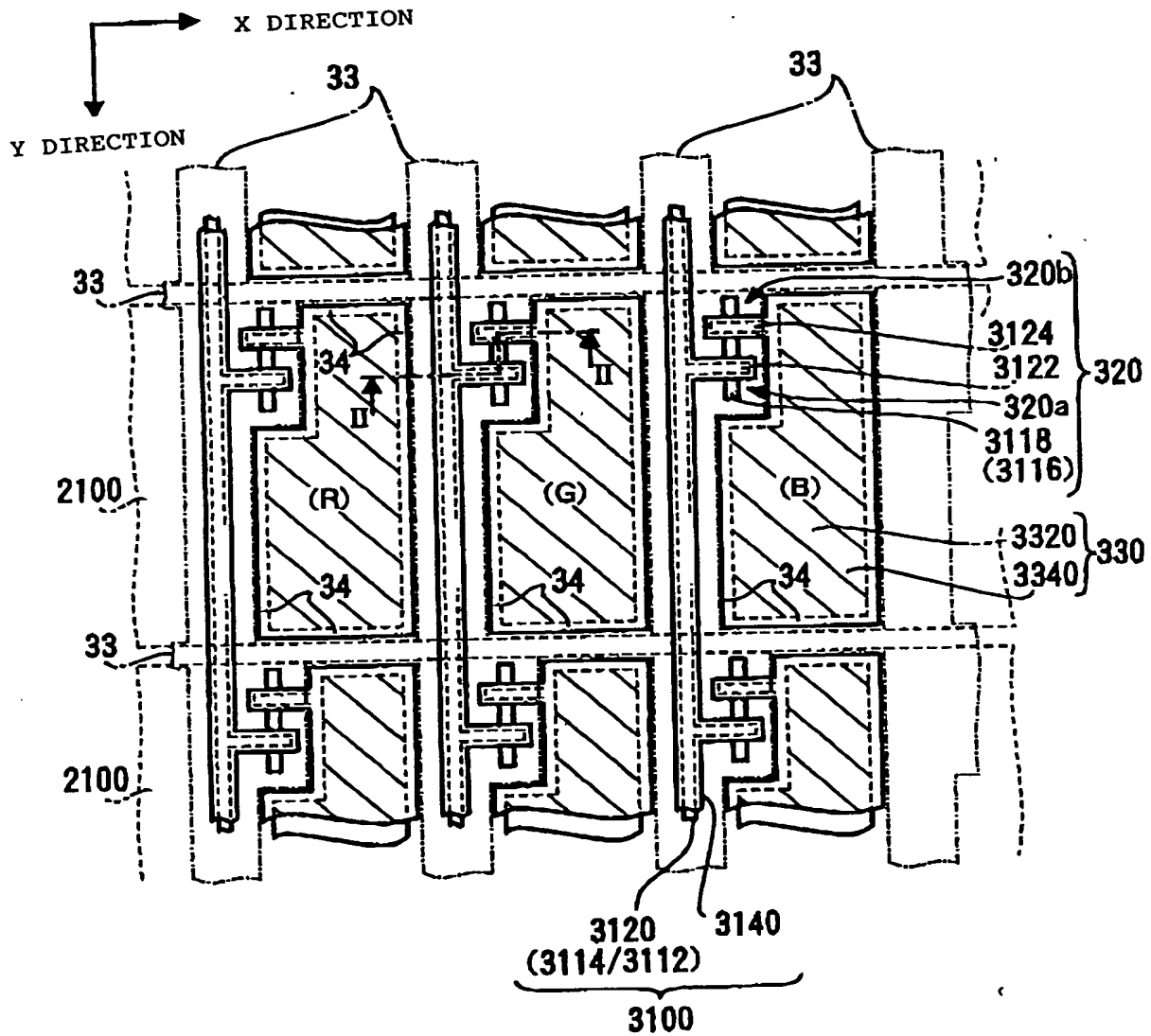


FIG. 22



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FIG. 23



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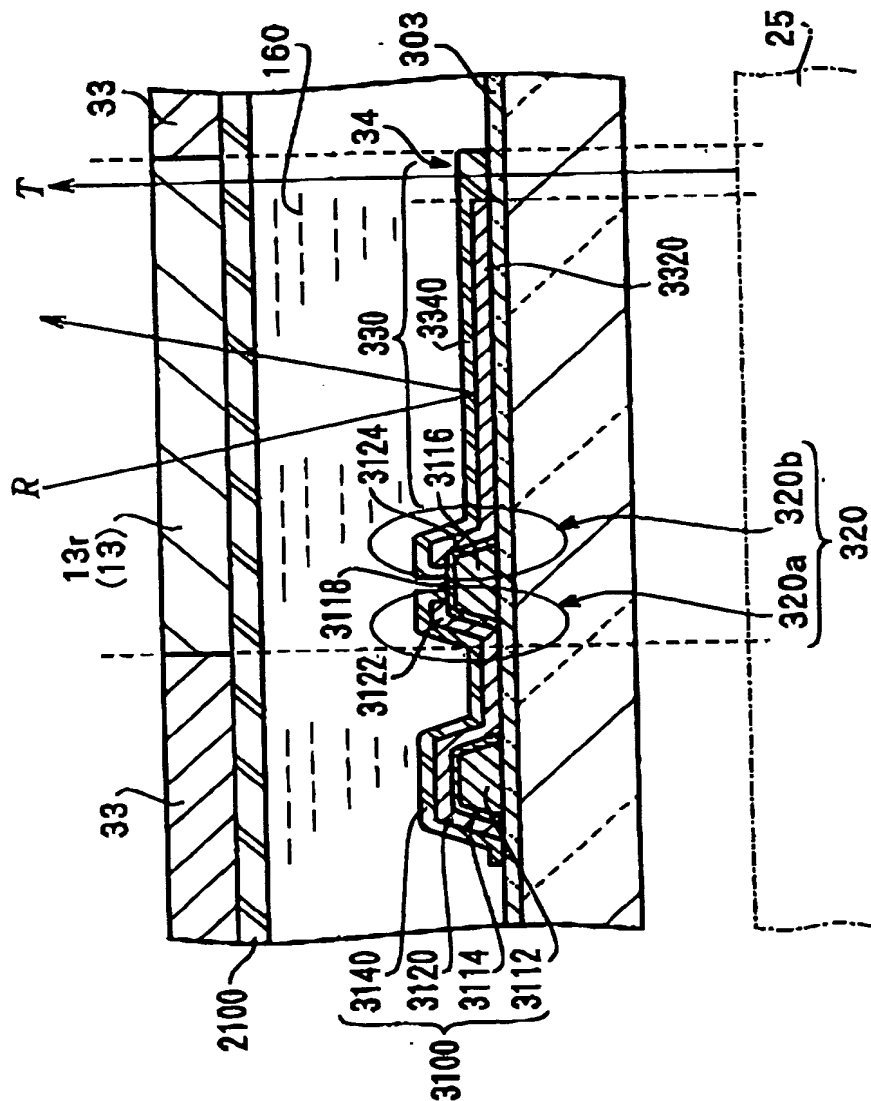
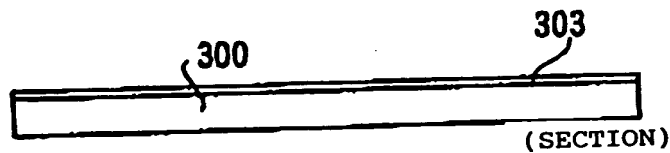
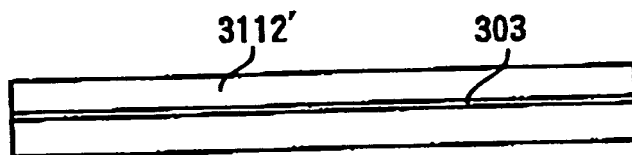


FIG. 25

(a) DEPOSITION OF UNDERLYING FILM



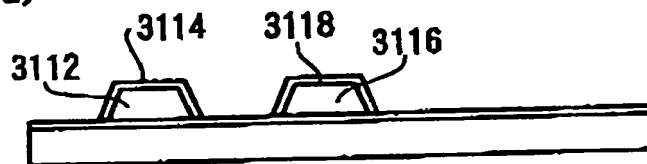
(b) DEPOSITION OF FIRST METAL FILM



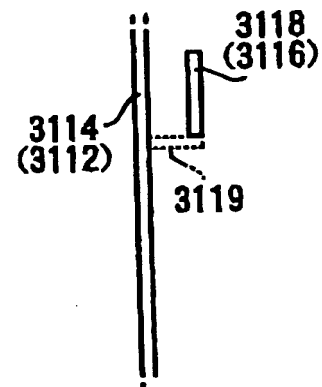
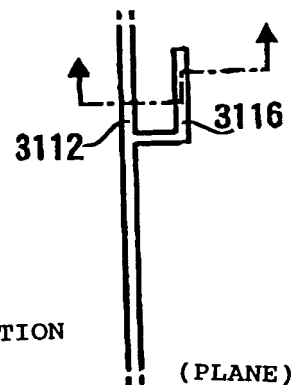
(c) PATTERNING OF FIRST METAL FILM



(d) FORMATION OF INSULATING FILM BY ANODIZATION



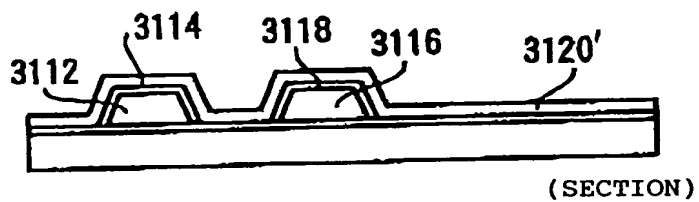
(e) ELEMENT SEPARATION



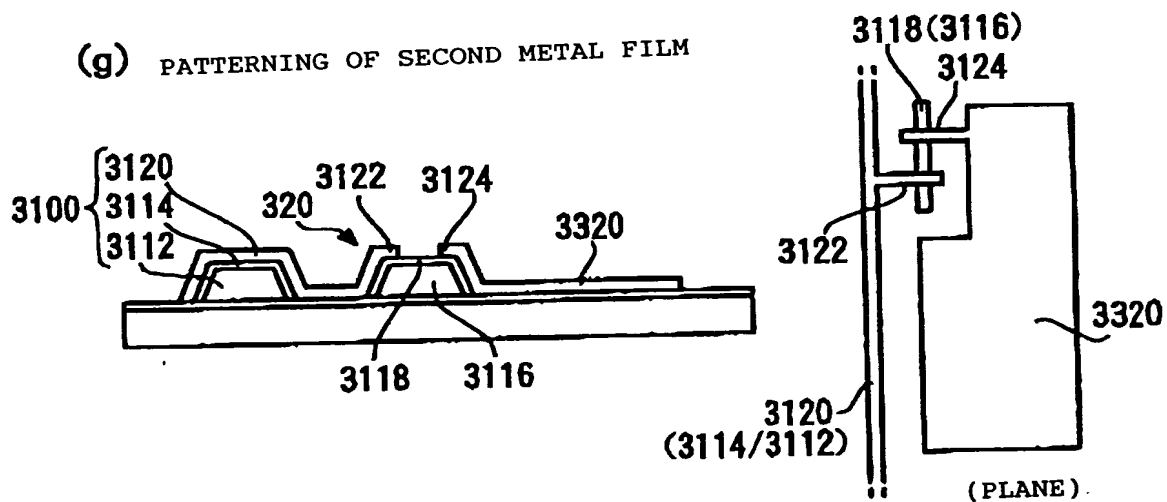
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FIG. 26

(f) DEPOSITION OF SECOND METAL FILM (SILVER ALLOY)



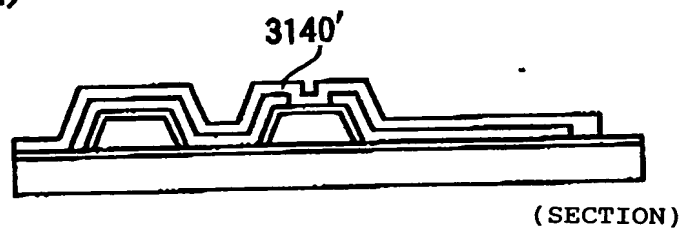
(g) PATTERNING OF SECOND METAL FILM



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FIG. 27

(h) DEPOSITION OF ITO



(i) PATTERNING OF ITO

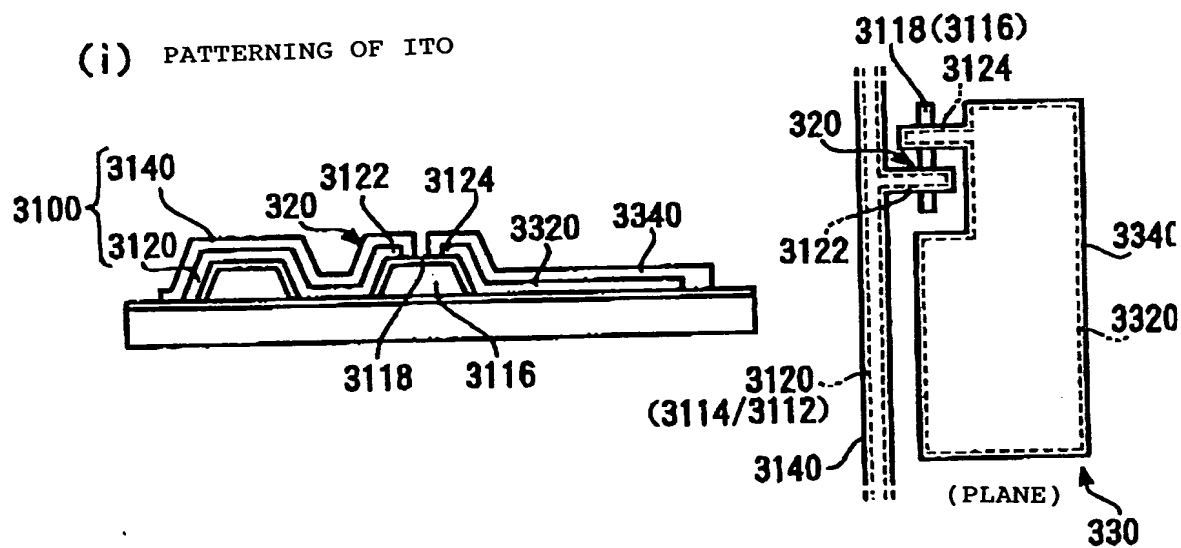
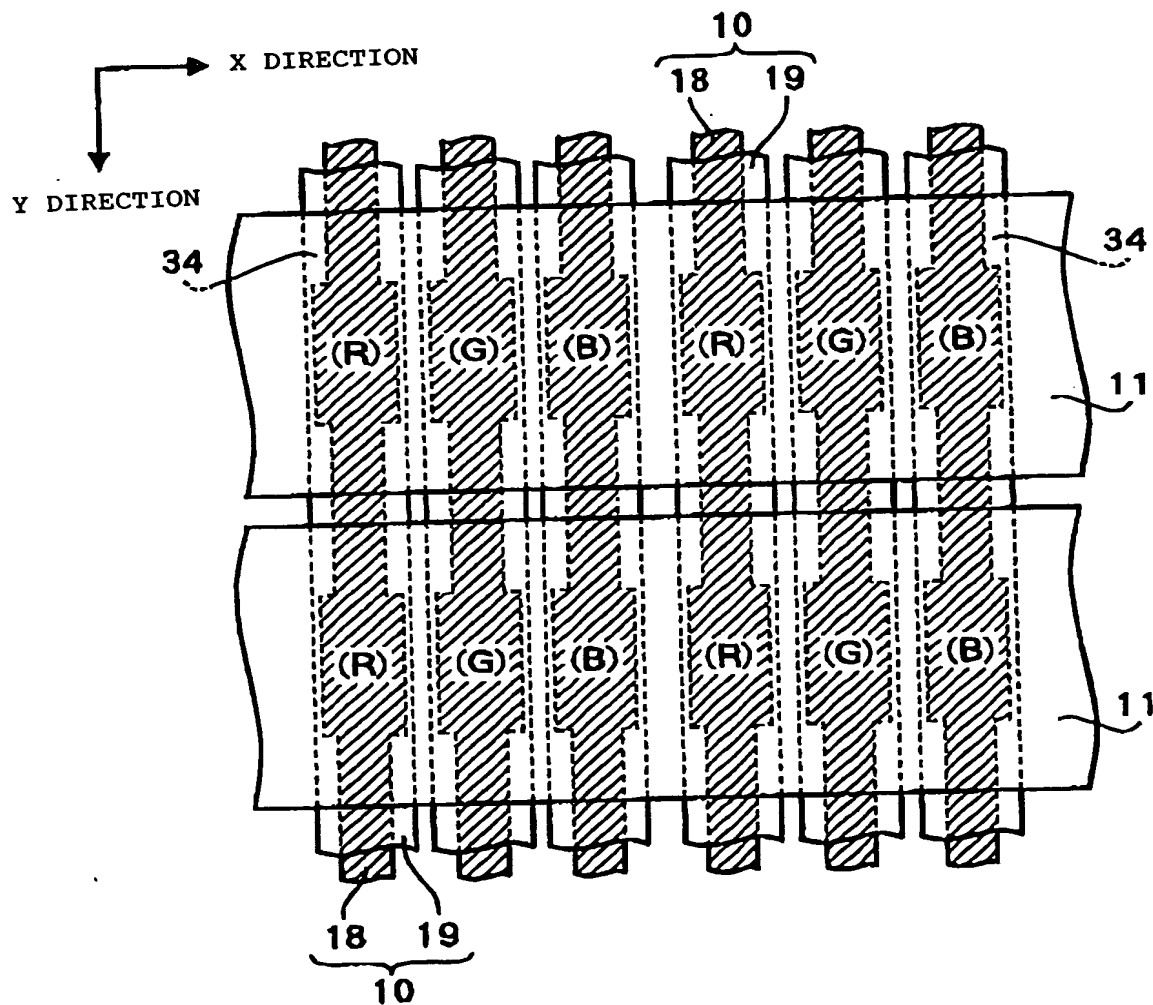
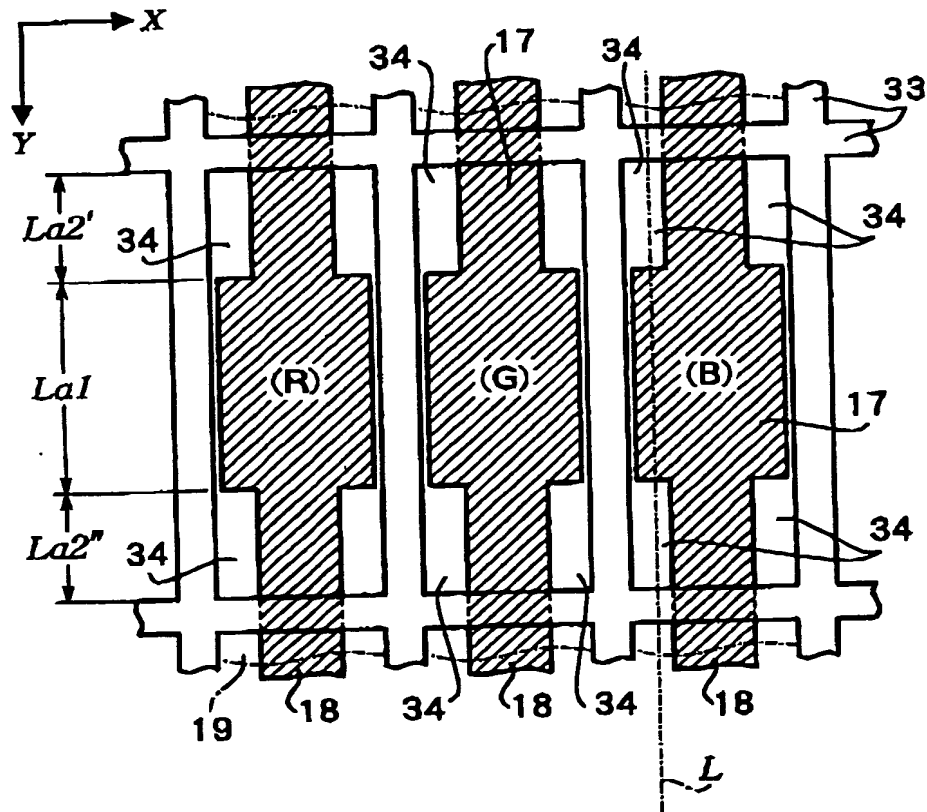


FIG. 28



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FIG. 29



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FIG. 30

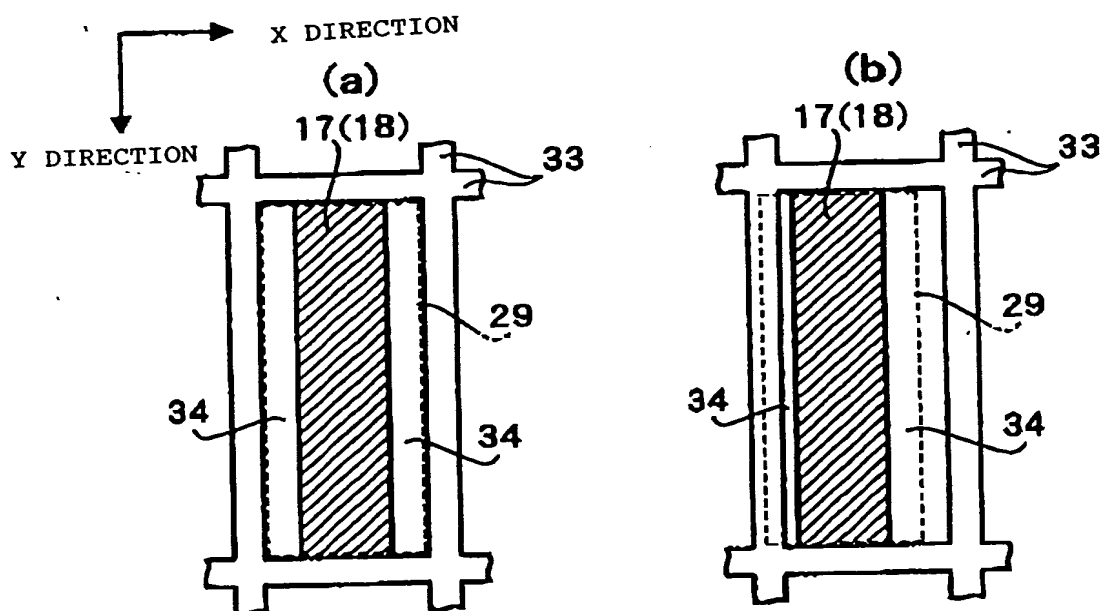
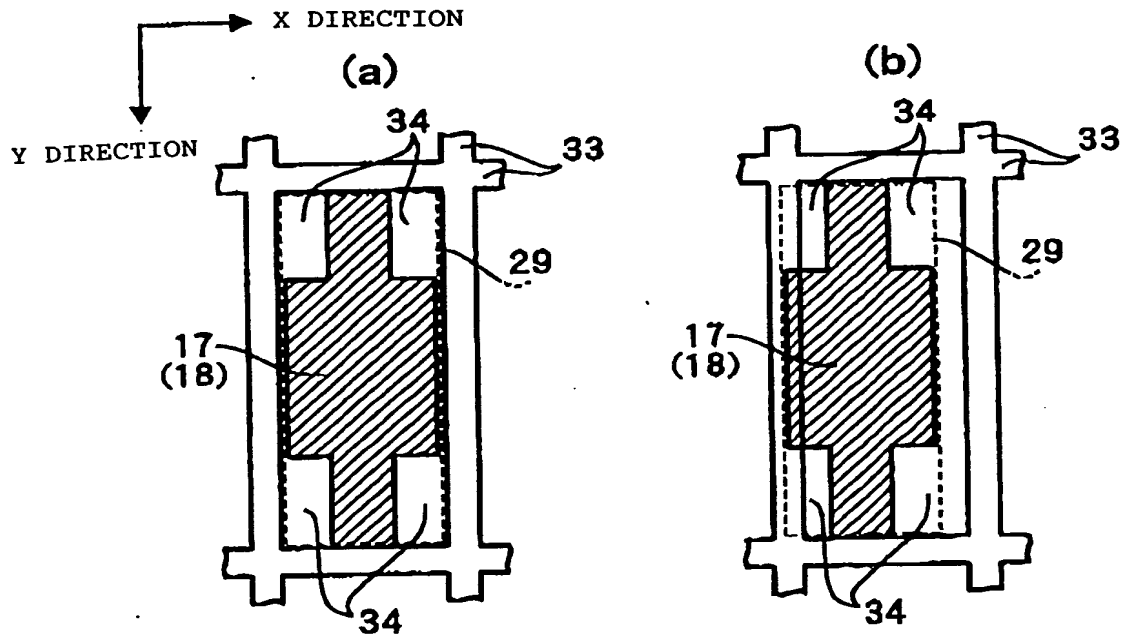


FIG. 31



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FIG. 32

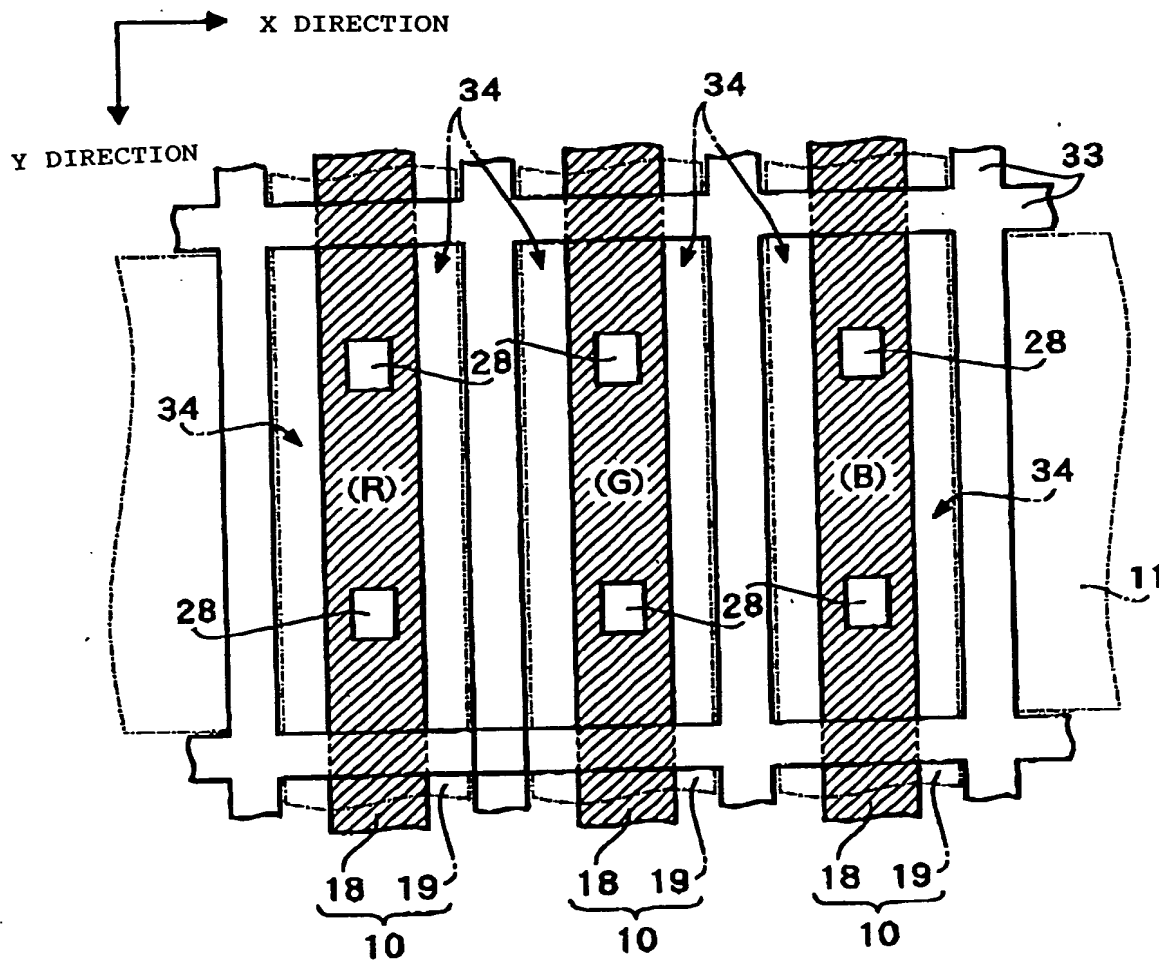
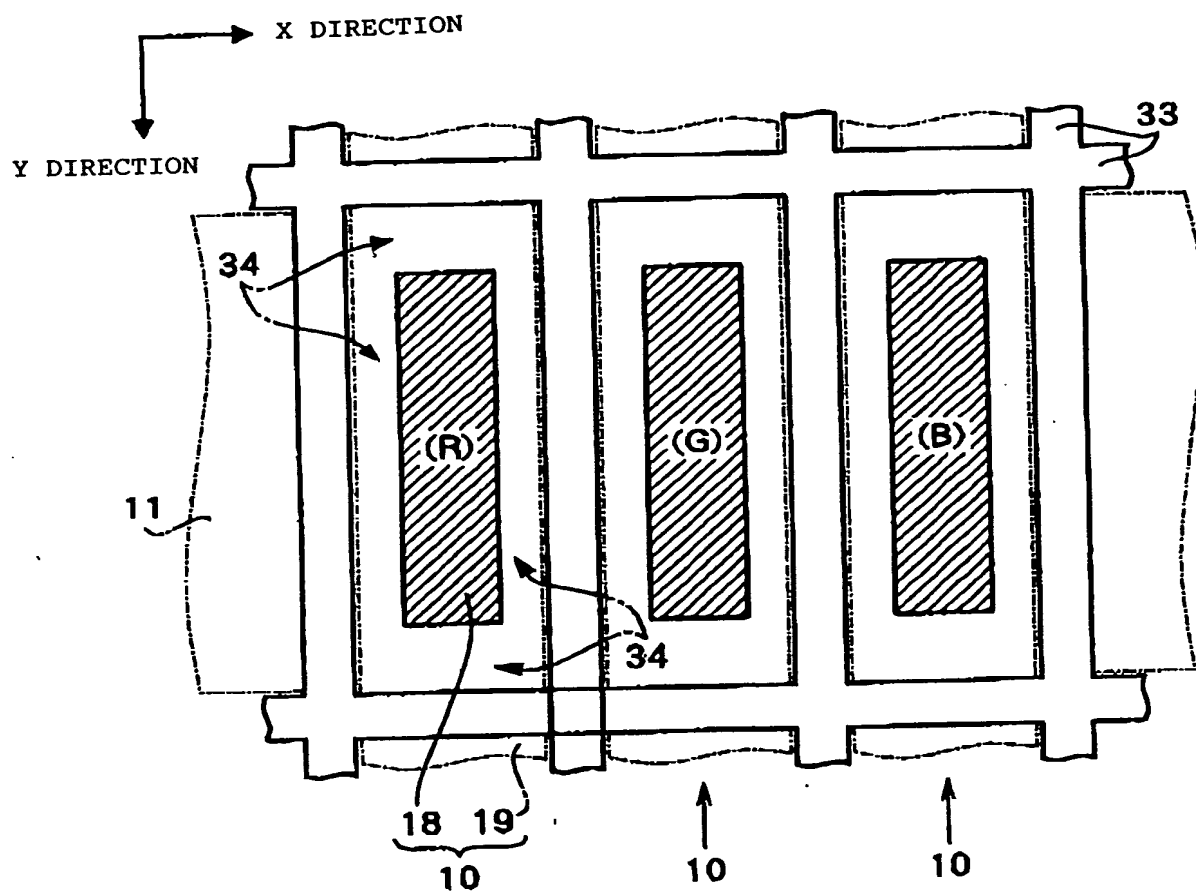


FIG. 33



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FIG. 34

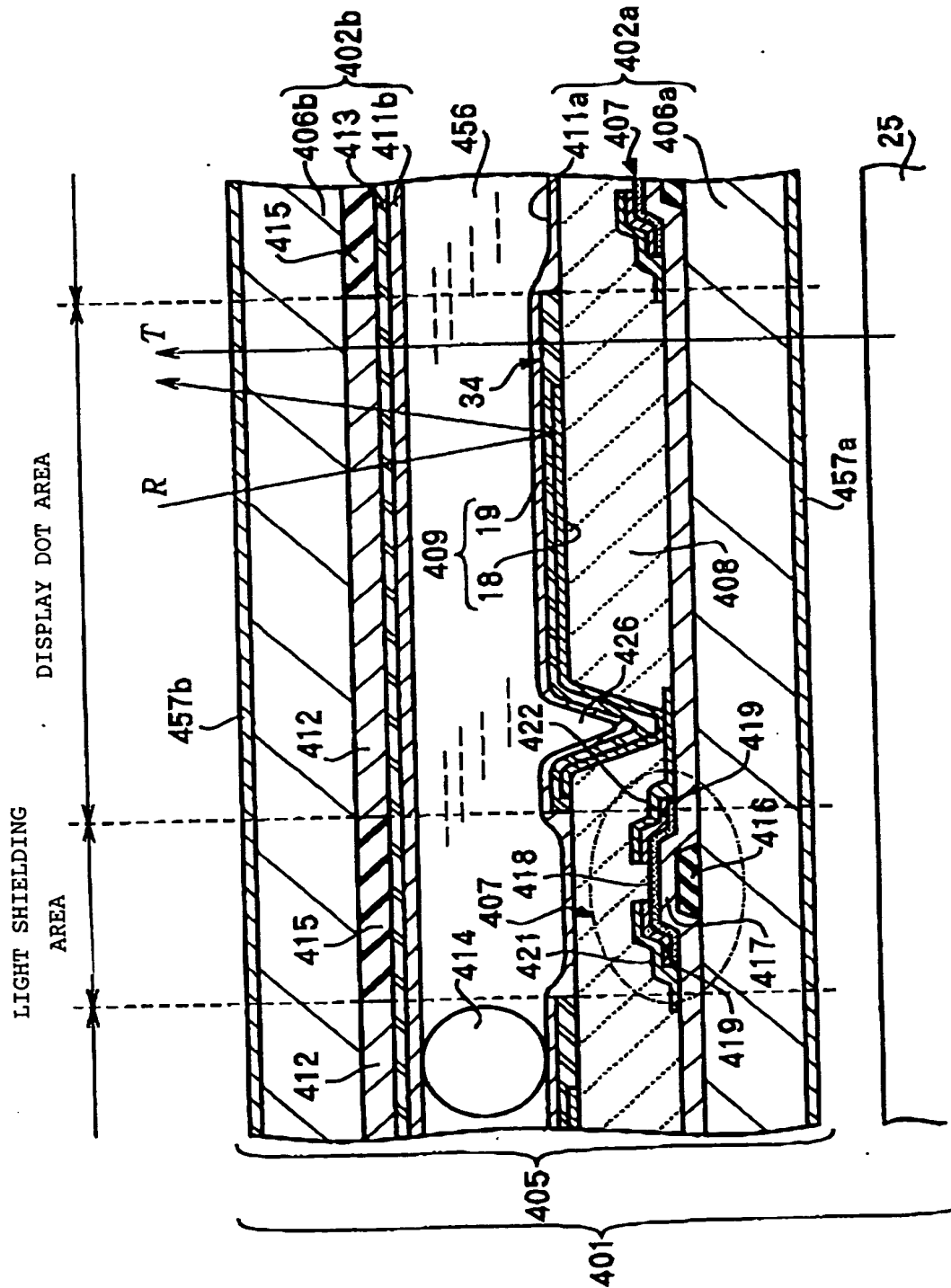
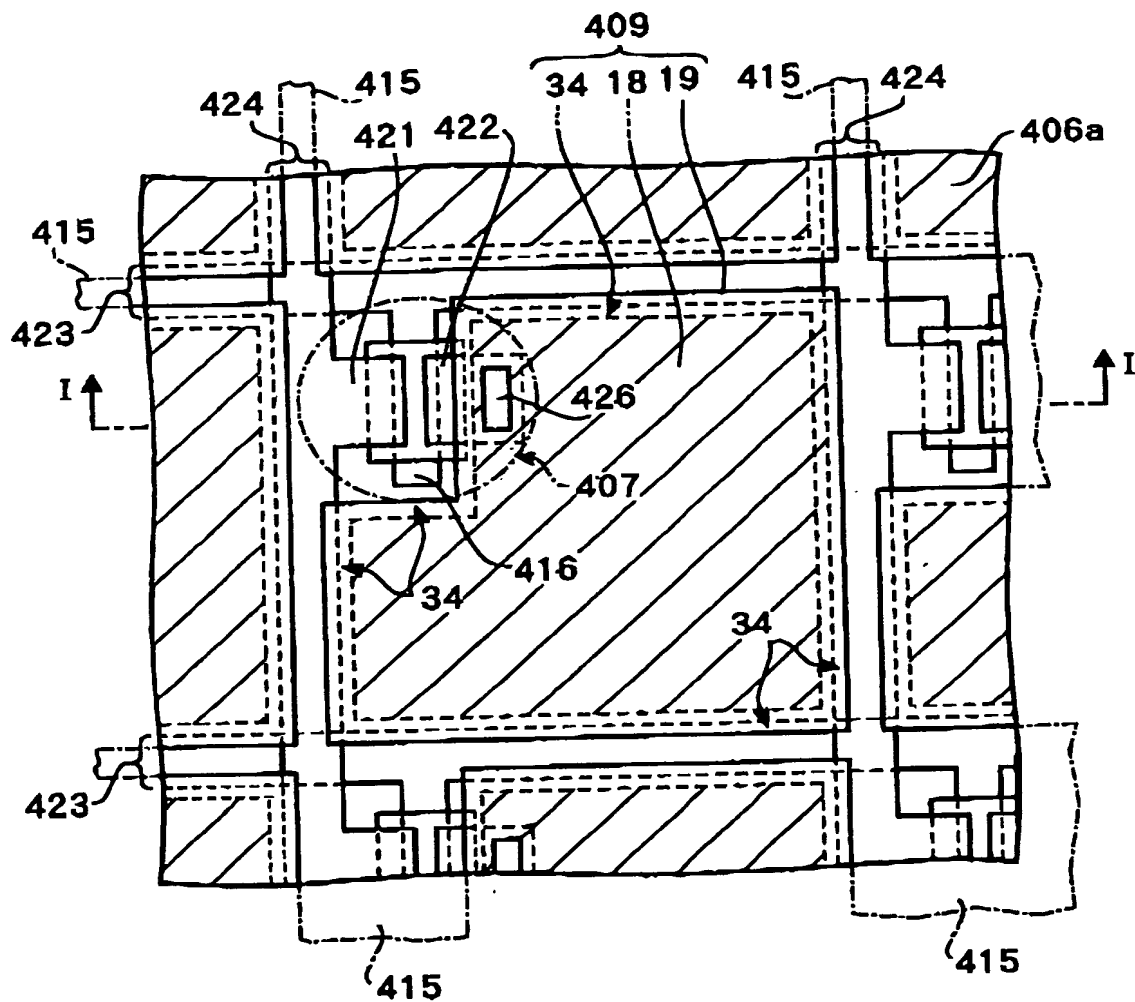
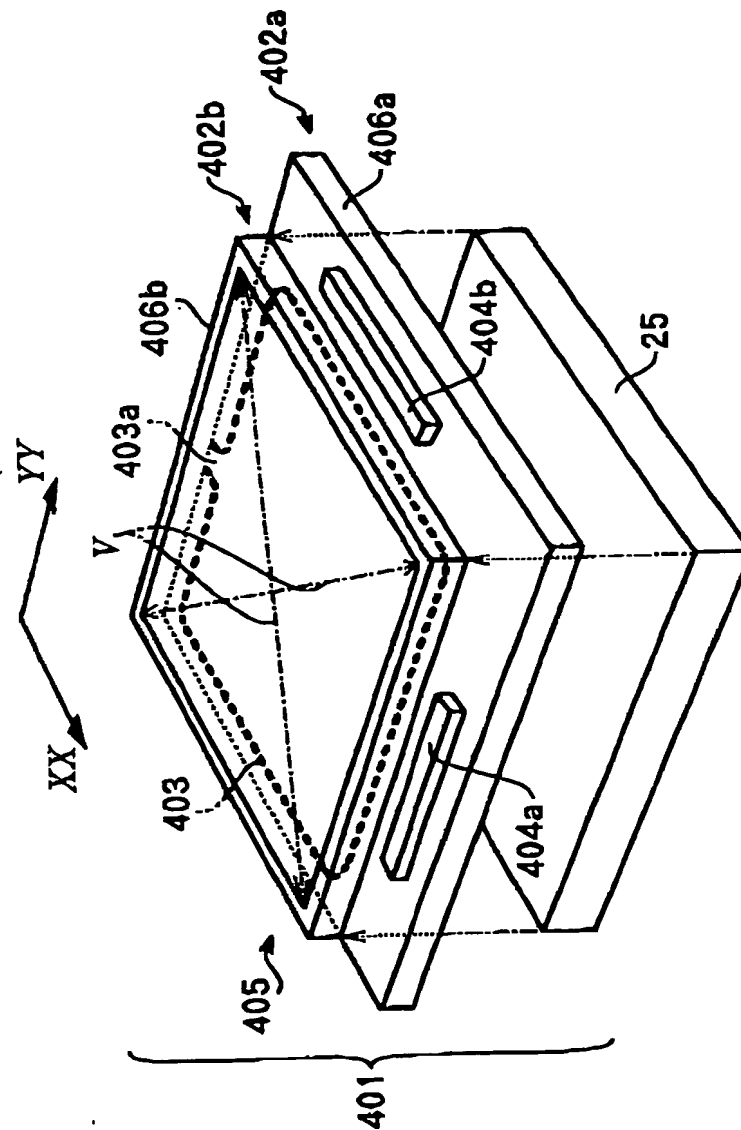


FIG. 35



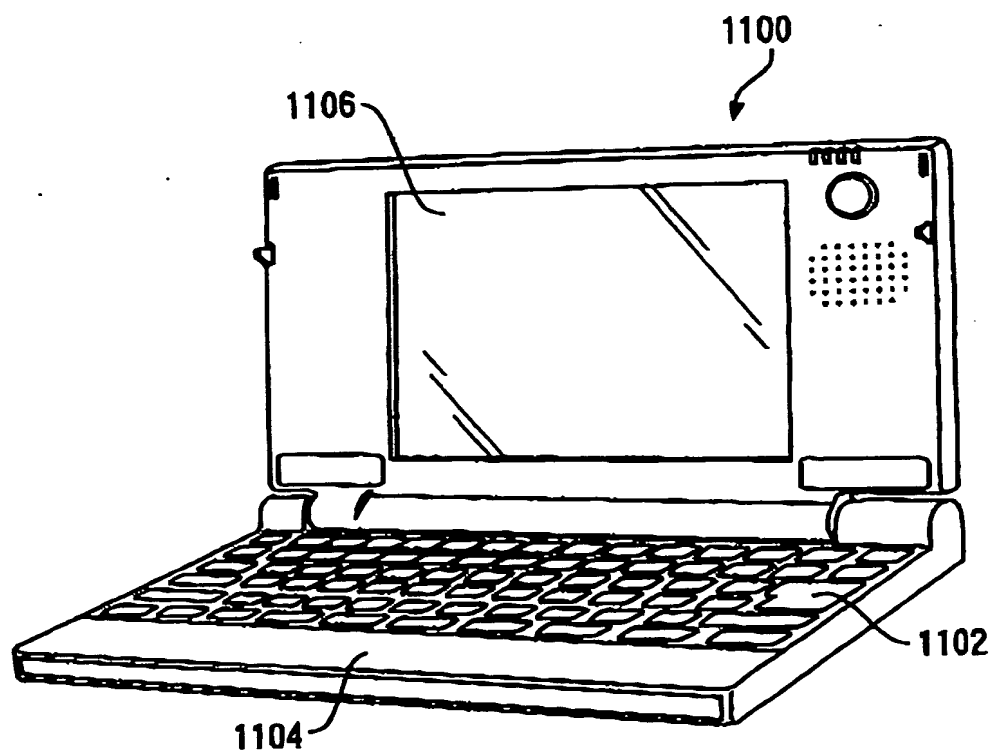
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FIG. 36



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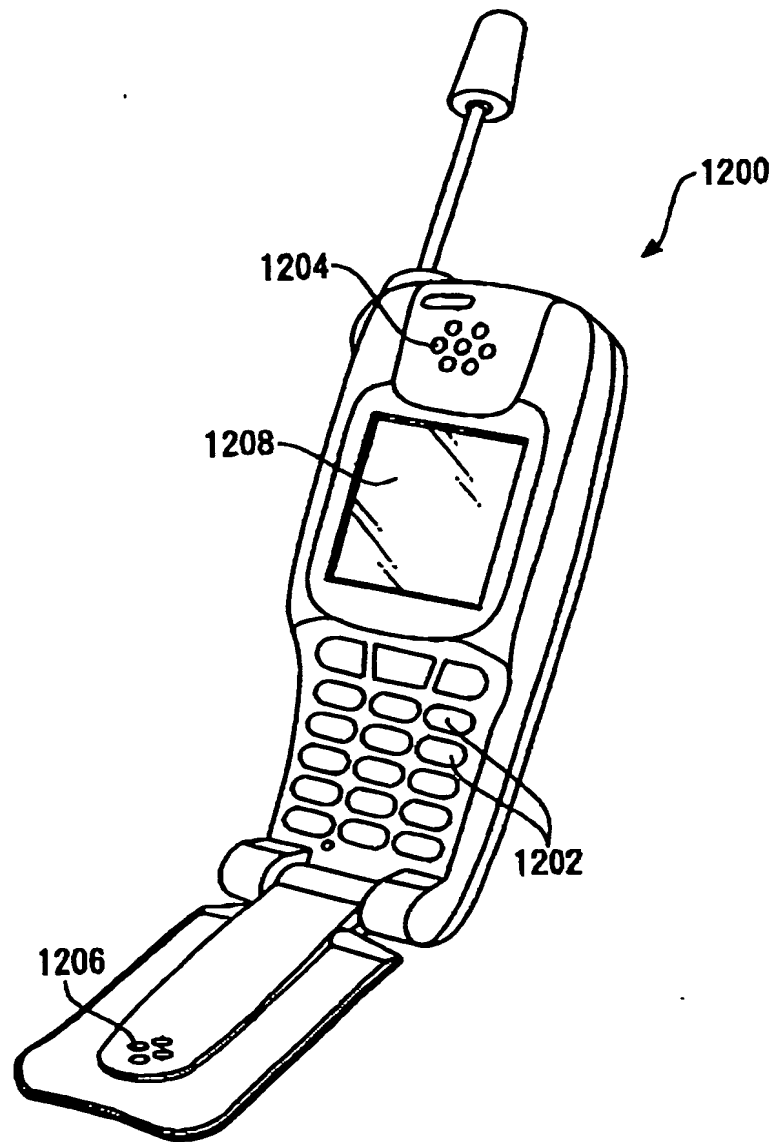
FIG. 37



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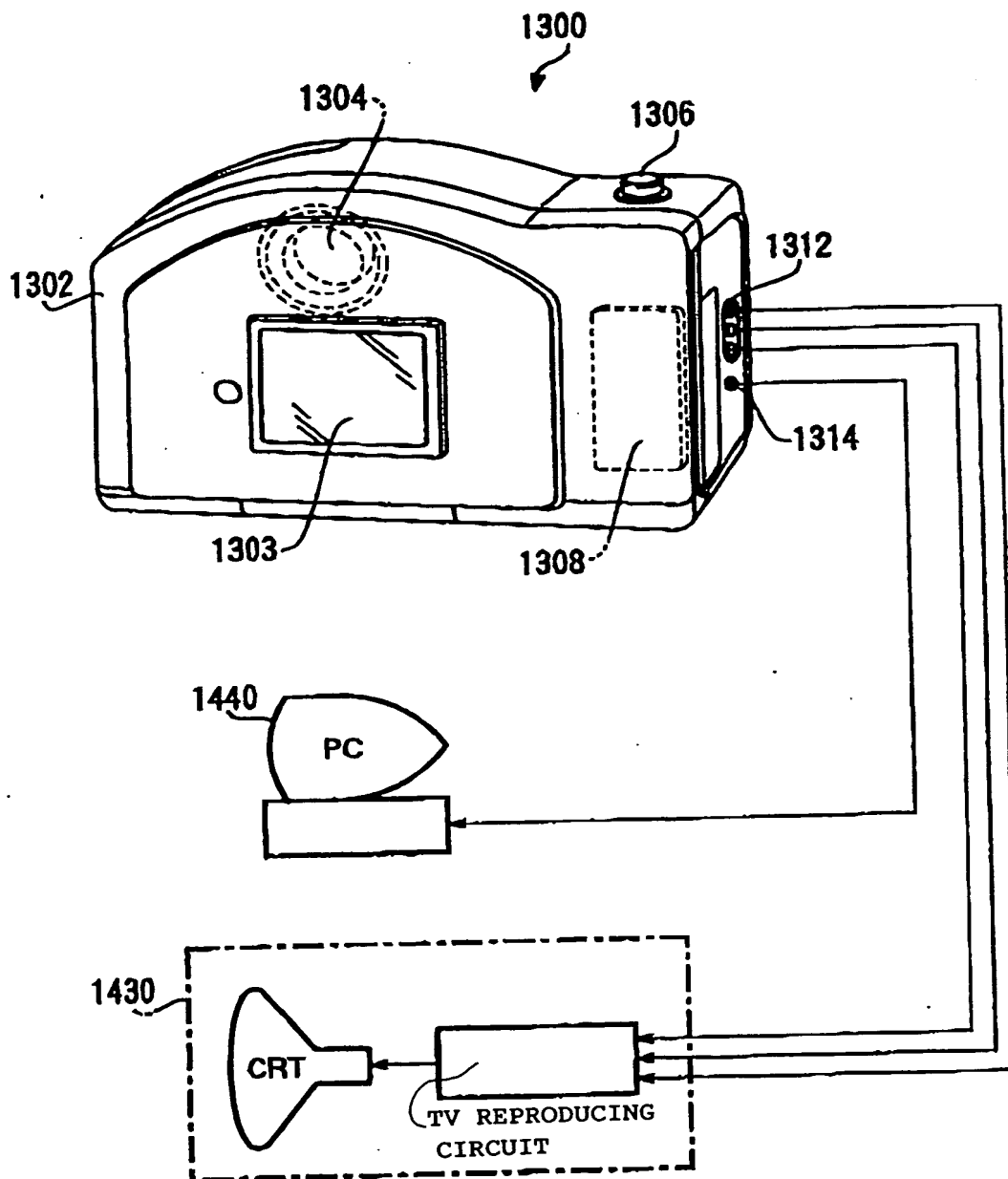
FIG. 38



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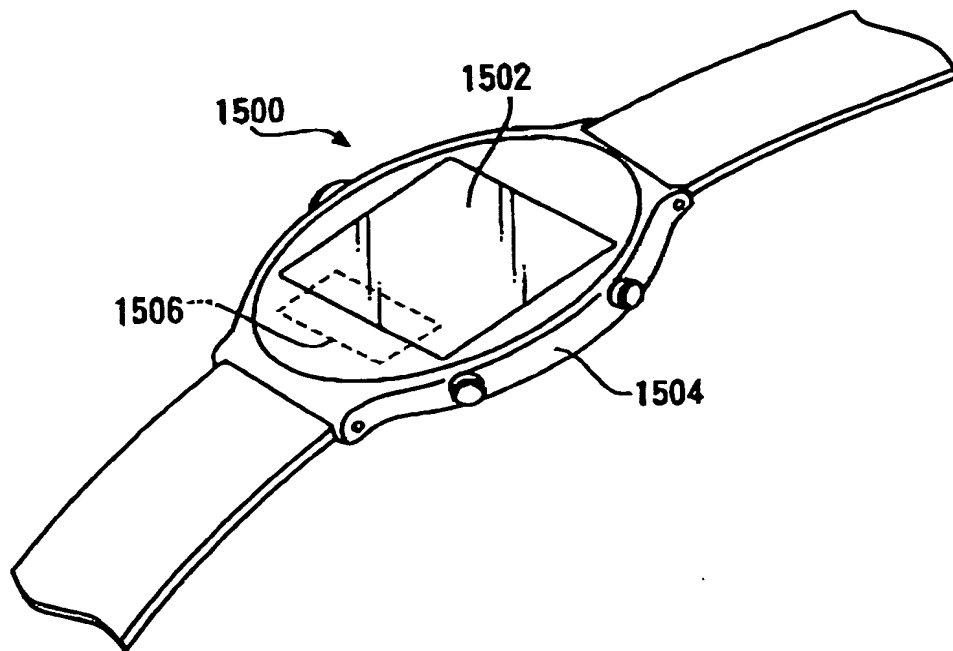
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FIG. 39



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FIG. 40



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